

Development of Silicon Photo-Multipliers (SiPMs) for Future Scintillation and Cherenkov Light Detectors.

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Outline

- Introduction / Motivation.
- How Do SiPMs Work.
- Characterization Model for SiPMs.
- Development of 3DSiPM.
- Boosting SiPMs VUV Efficiency.
- Precisions-Physics / Commercial Applications
- Conclusions.

Introduction / Motivation

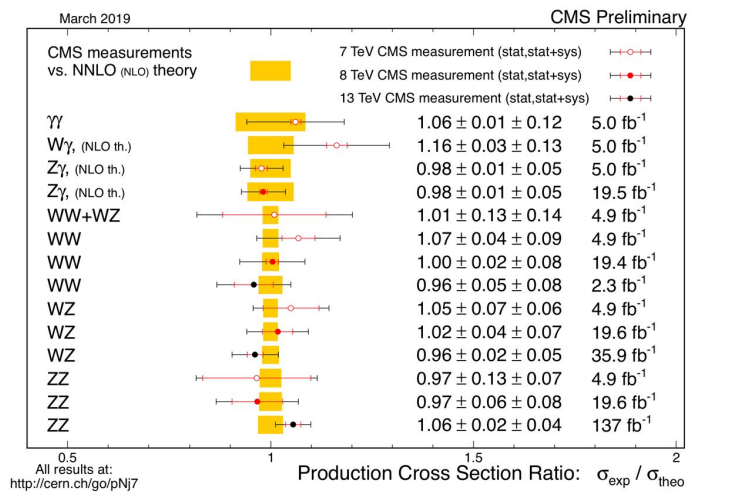
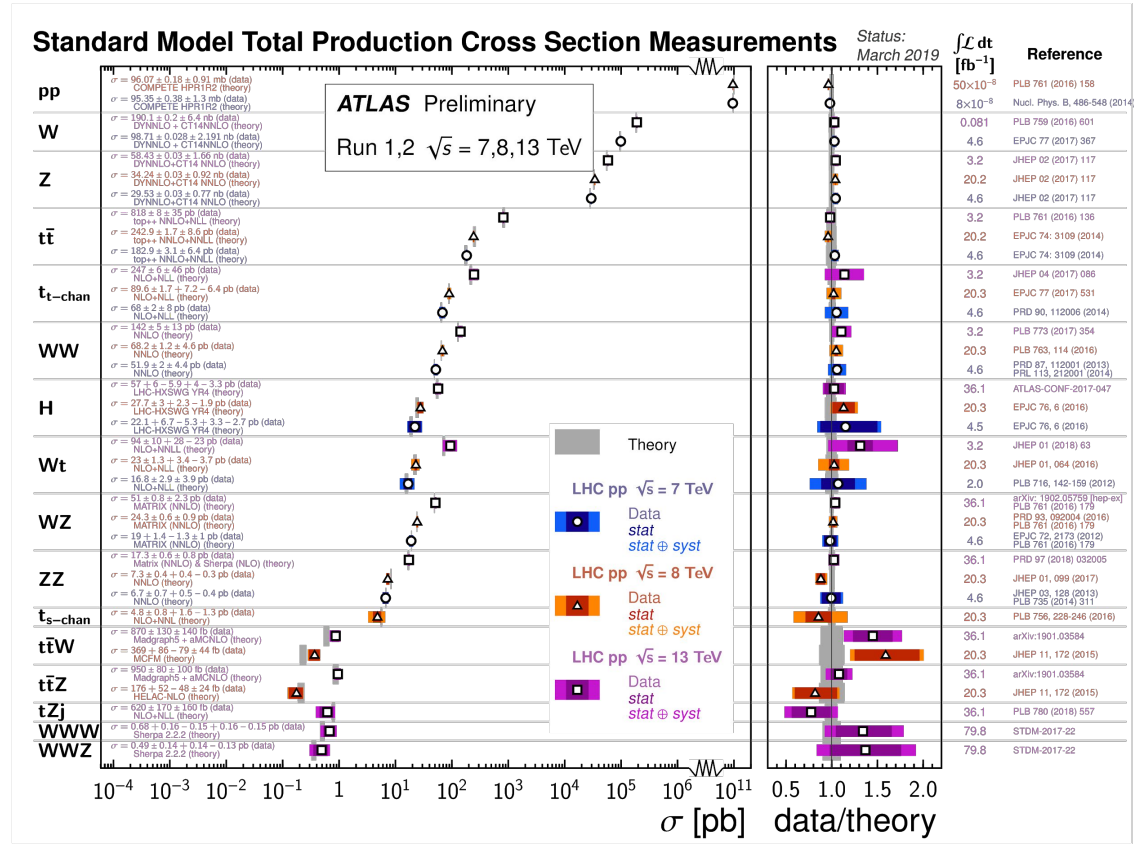
three generations of matter
(fermions)

SCALAR BOSONS

GAUGE BOSONS

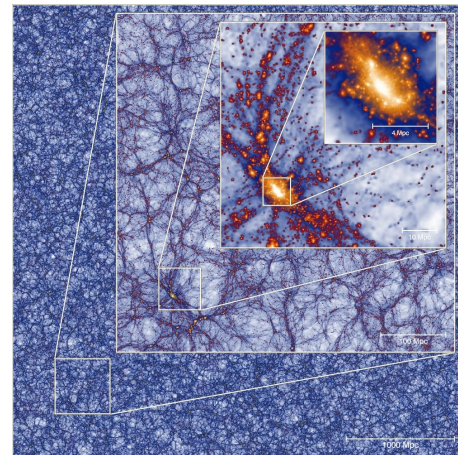
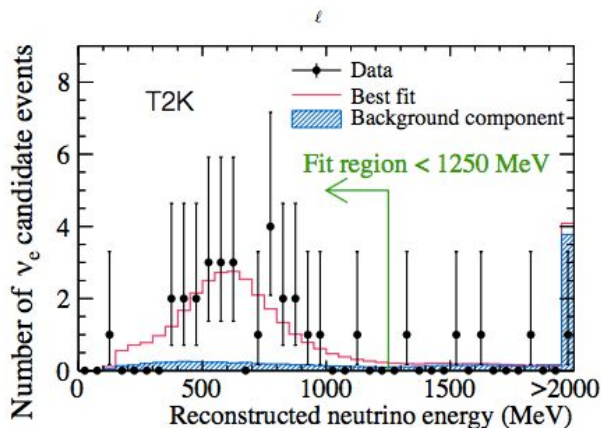
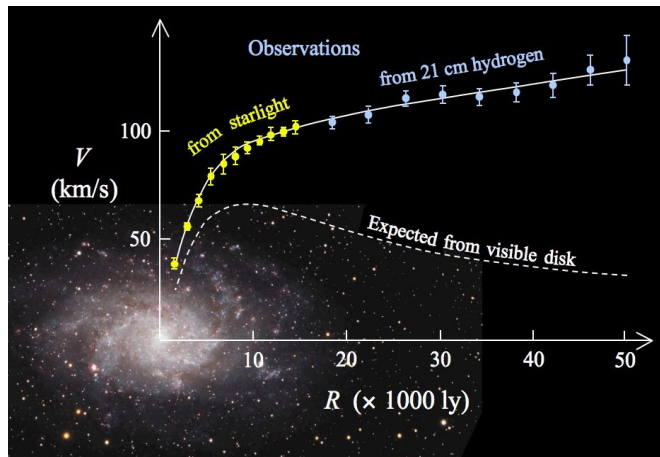
- **1897:** Discovery of the electron (J.J. Thomson).
- **1956:** Discovery of the electron neutrino (Cowan-Reines).
- **1962:** Discovery of the muon neutrino (Lderman-Schwartz).
- **1968:** Discovery of the up, down quarks (SLAC).
- **1974:** Discovery of the charm quark (SLAC and BNL).
- **1977:** Discovery of the bottom quark (FERMIIlab).
- **1978:** Discovery of the gluon (DESY)
- **1983:** Discovery of the W and Z bosons (CERN).
- **1995:** Discovery of the top quark (CDF and D0).
- **2000:** Discovery of the tau neutrino (DONUT).
- **2013:** Discovery of the Higgs boson (CERN).

The Standard Model Works at an Extremely High Precision



.... But There Are Still Open Questions

6



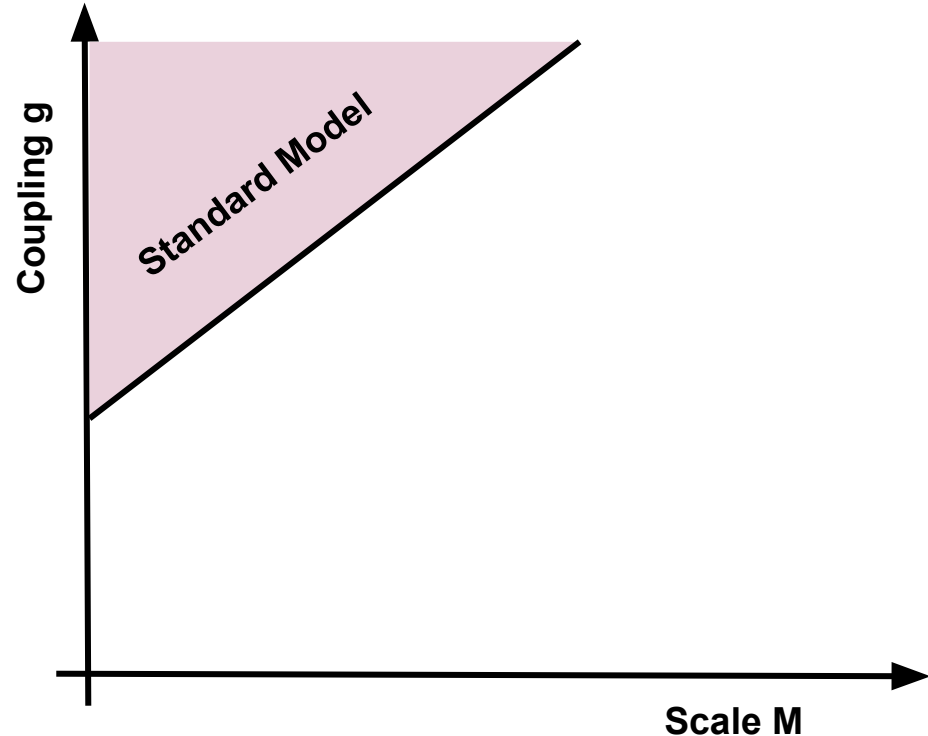
- What is Dark Matter?
- Why Neutrinos have masses?
- What causes the Matter-AntiMatter Asymmetry?
- What drives large-scale Galaxies formations?
- What about Gravity?
- MORE

Life at the Frontier of the Standard Model

7



We can generally parametrize new effects in terms of coupling (g) and energy distance⁻¹ scale.

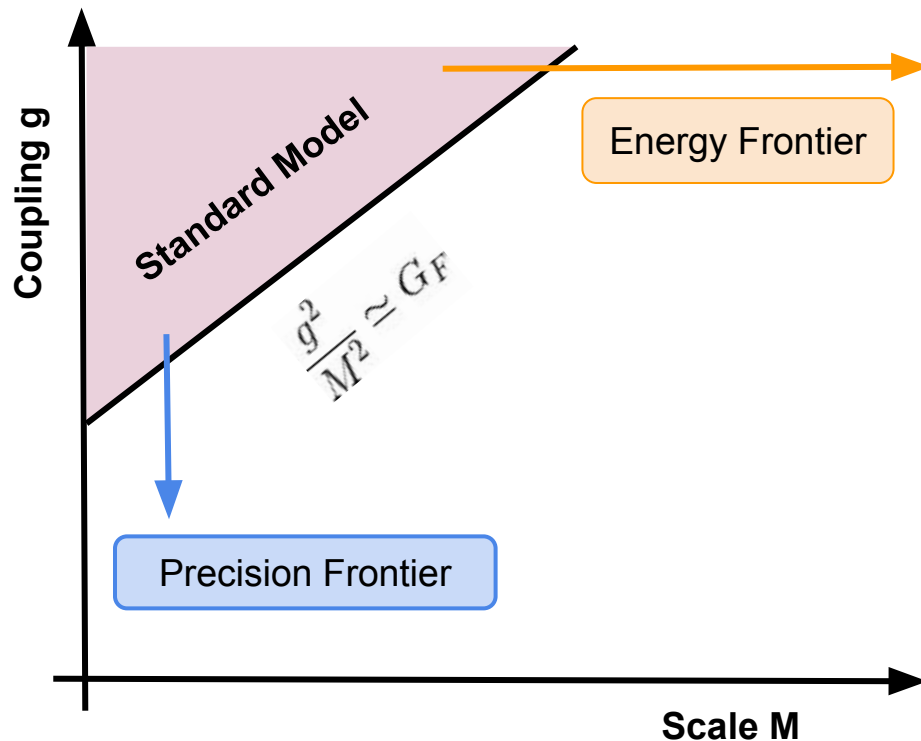


Life at the Frontier of the Standard Model

8



We can generally parametrize new effects in terms of coupling (g) and energy distance⁻¹ scale.

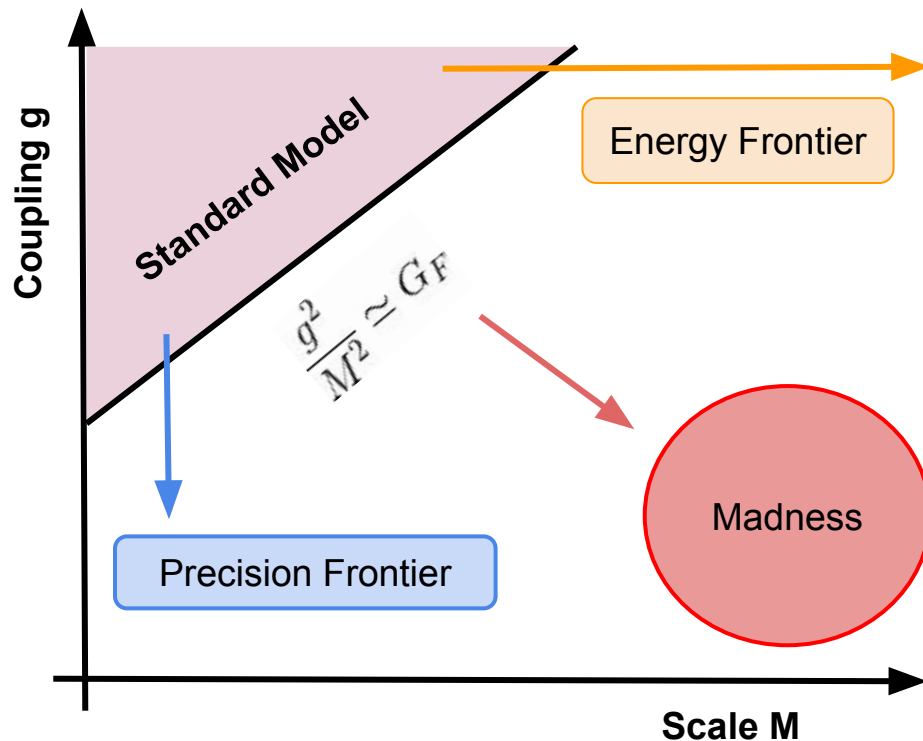


Life at the Frontier of the Standard Model

9



We can generally parametrize new effects in terms of coupling (g) and energy distance⁻¹ scale.



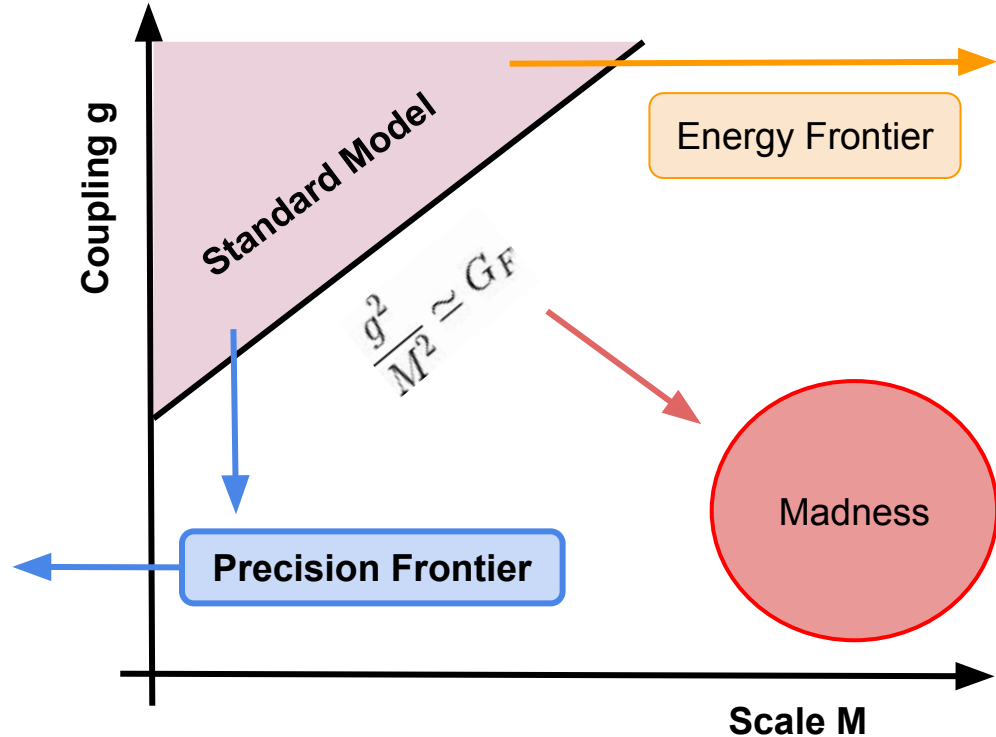
Life at the Frontier of the Standard Model

10



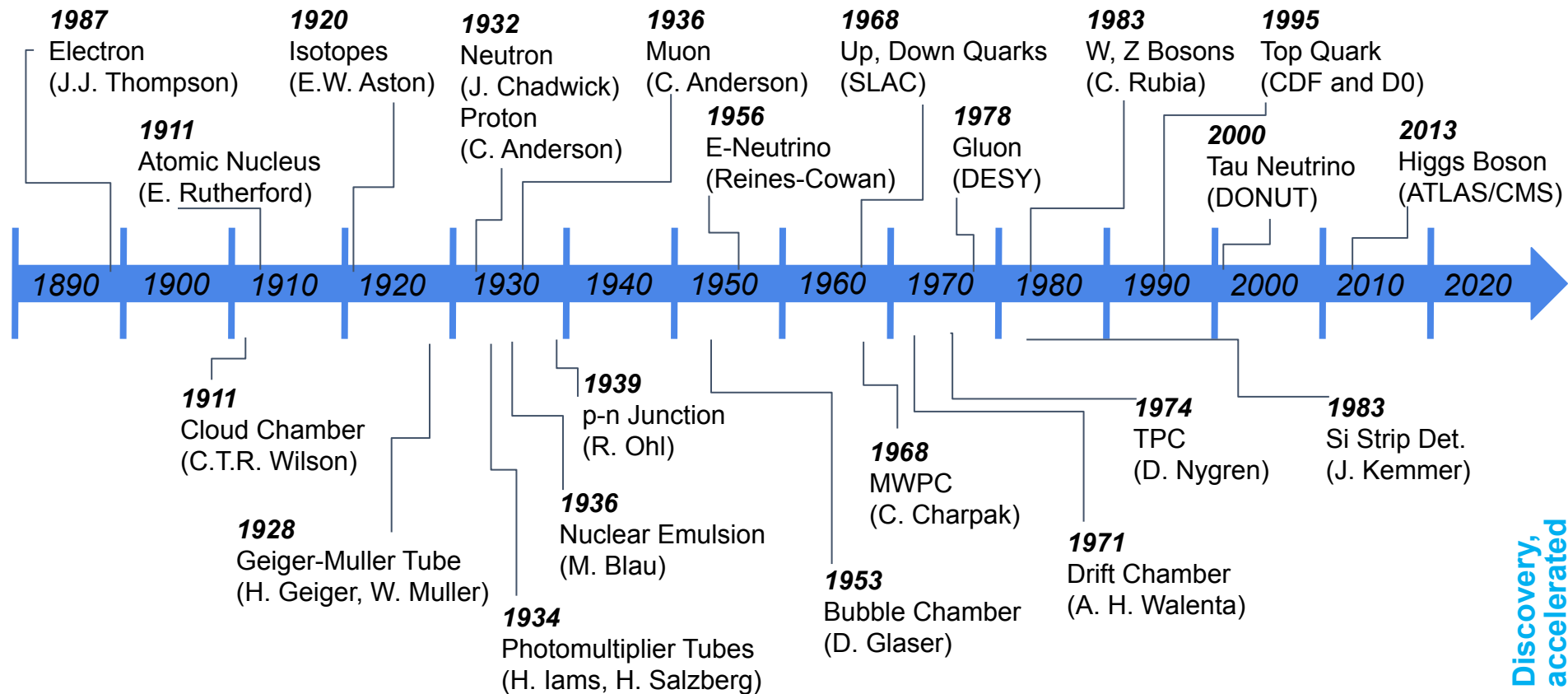
This requires new ideas and innovative technologies.

[Me: Dark Matter, Neutrino and Ultra-Cold Neutron]



Timeline of Particle Physics and Technology Development

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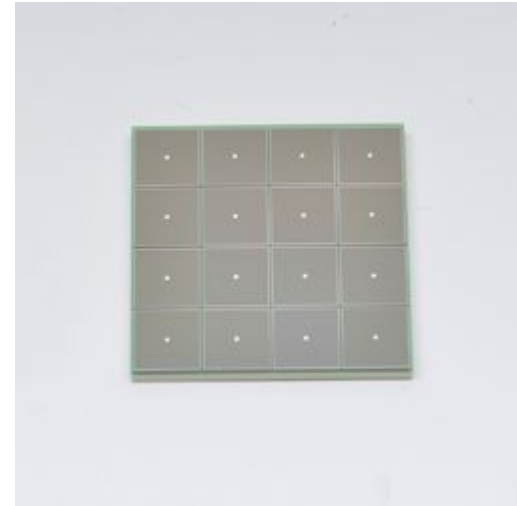
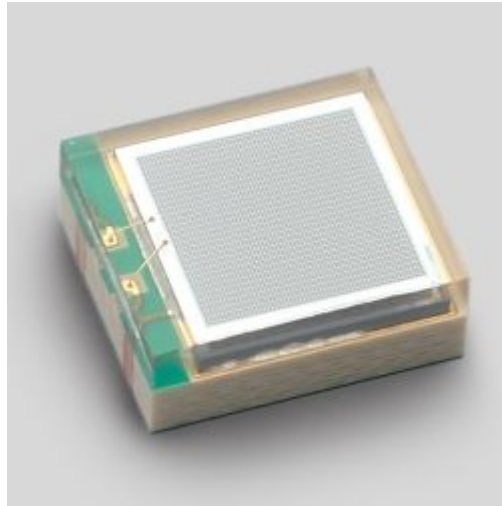


How Do SiPMs Work?

How Do SiPMs Work?

13

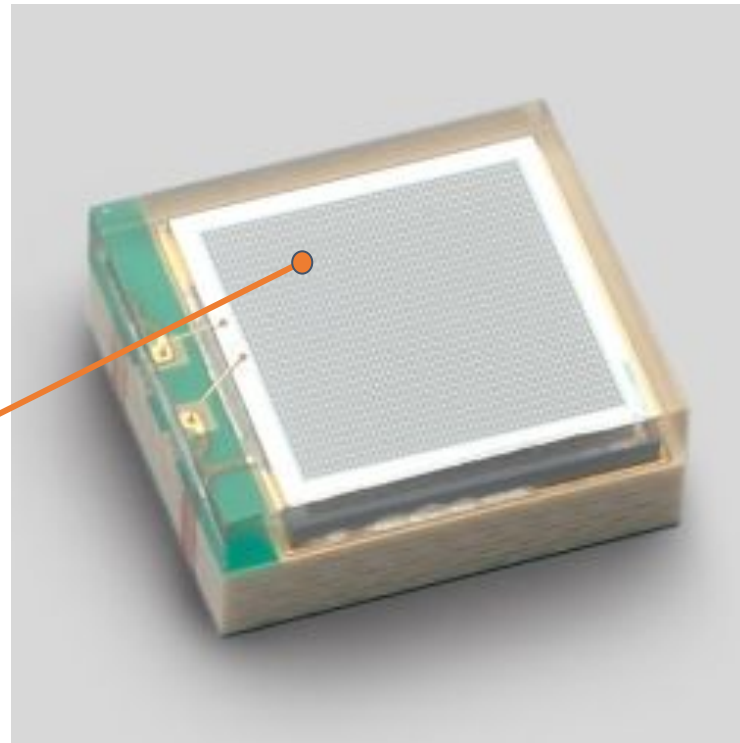
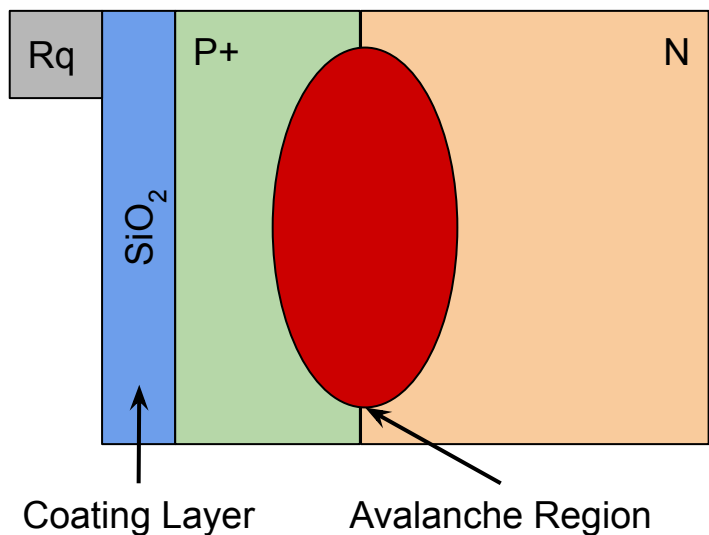
Silicon Solid State Devices, using the photoelectric effect to convert photons to electron/hole pair.
Primarily, rely on p-n junctions for carrier amplification.



How Do SiPMs Work? Solid-State Approach

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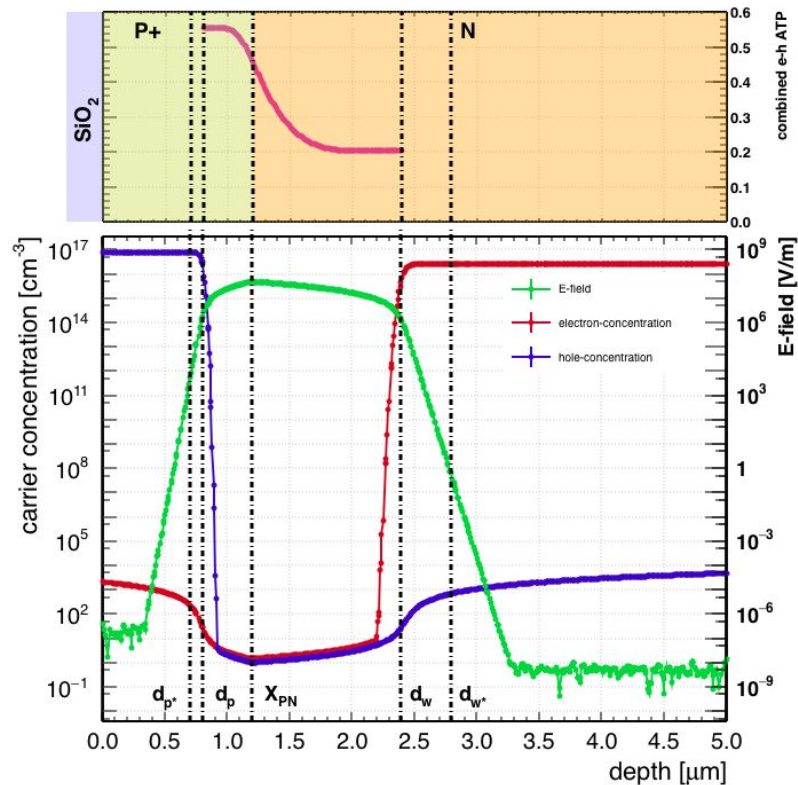
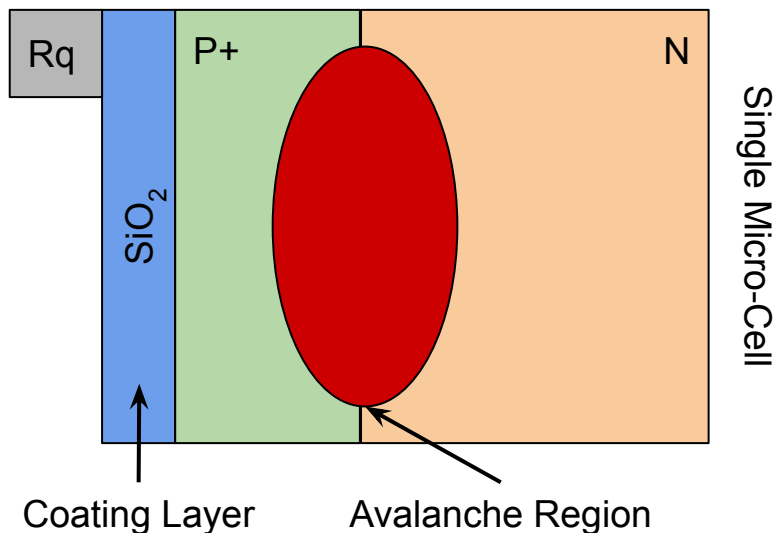
p-n junctions micro-cells operated in Geiger-mode, with an added quenching resistor. Each SiPM is composed by multiple micro-cells.



How Do SiPMs Work? Solid-State Approach

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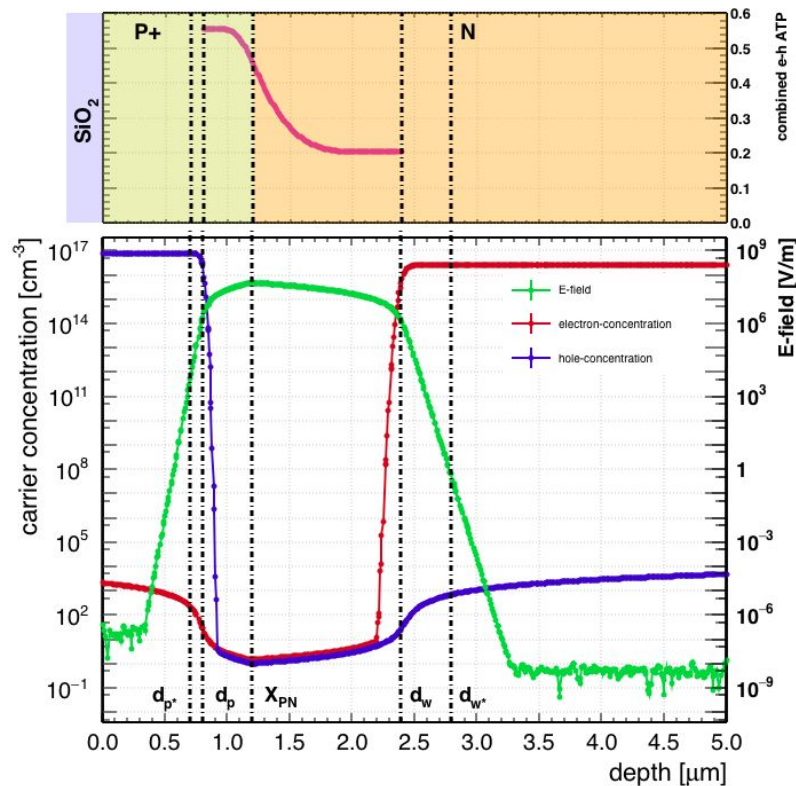
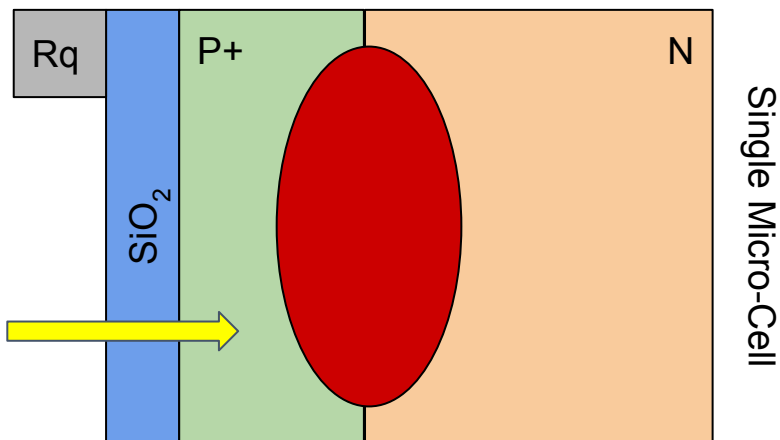
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How Do SiPMs Work? Solid-State Approach

16

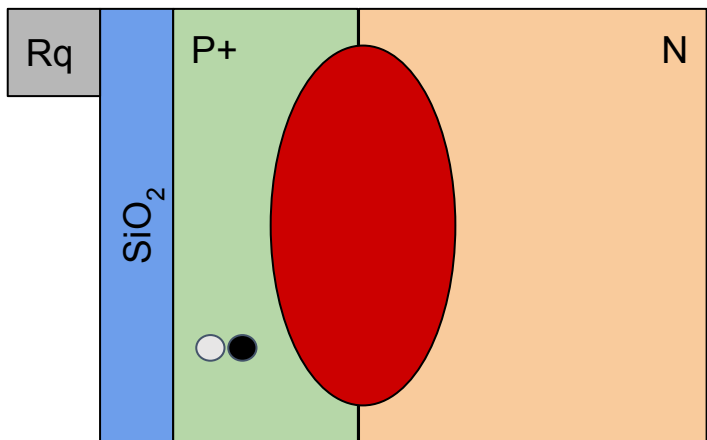
An incoming photon enters the junction and it is absorbed (wavelength dependent process).



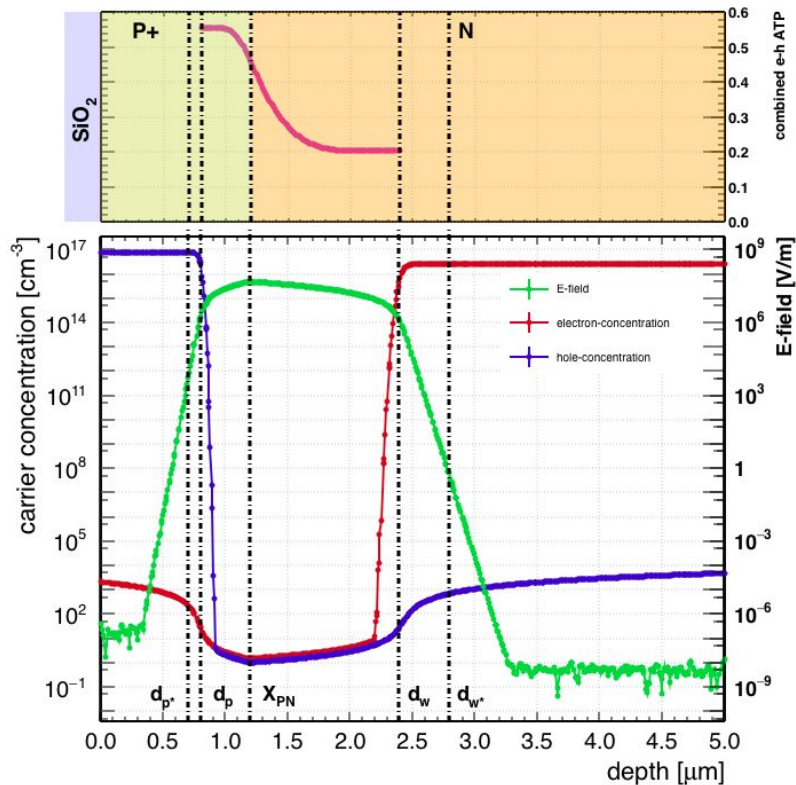
How Do SiPMs Work? Solid-State Approach

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The absorbed photons generates an electron-hole pair in the absorption region.



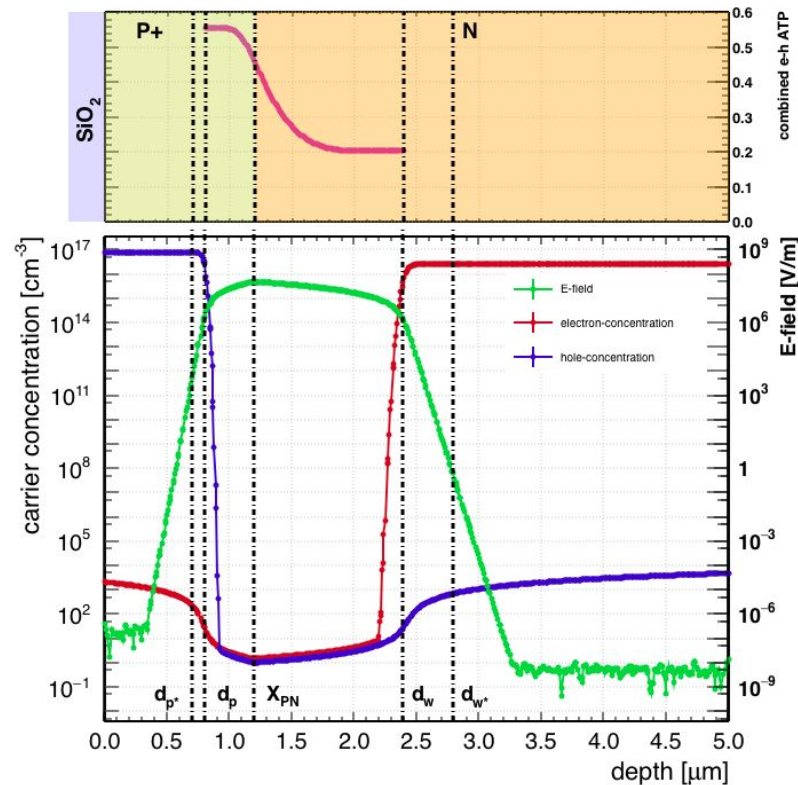
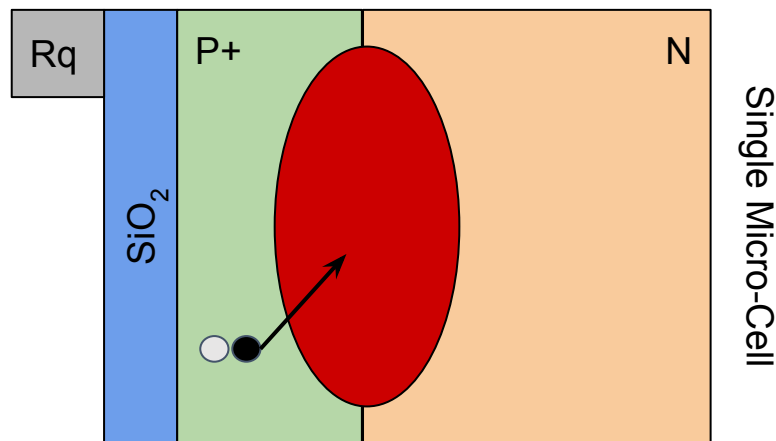
Single Micro-Cell



How Do SiPMs Work? Solid-State Approach

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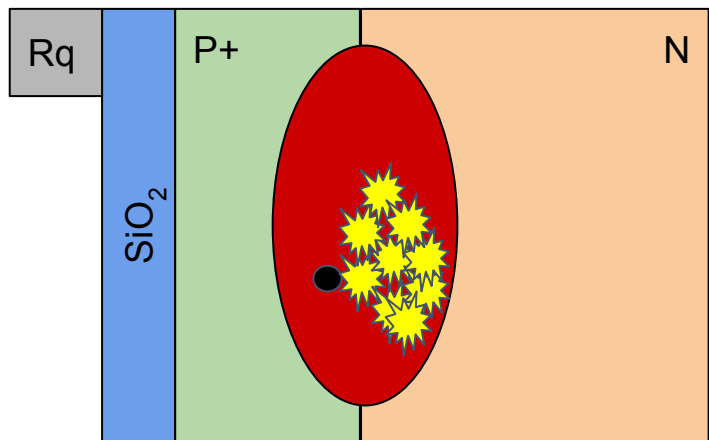
The internal field of the junction brings the generated carrier (e/h) to the avalanche region.



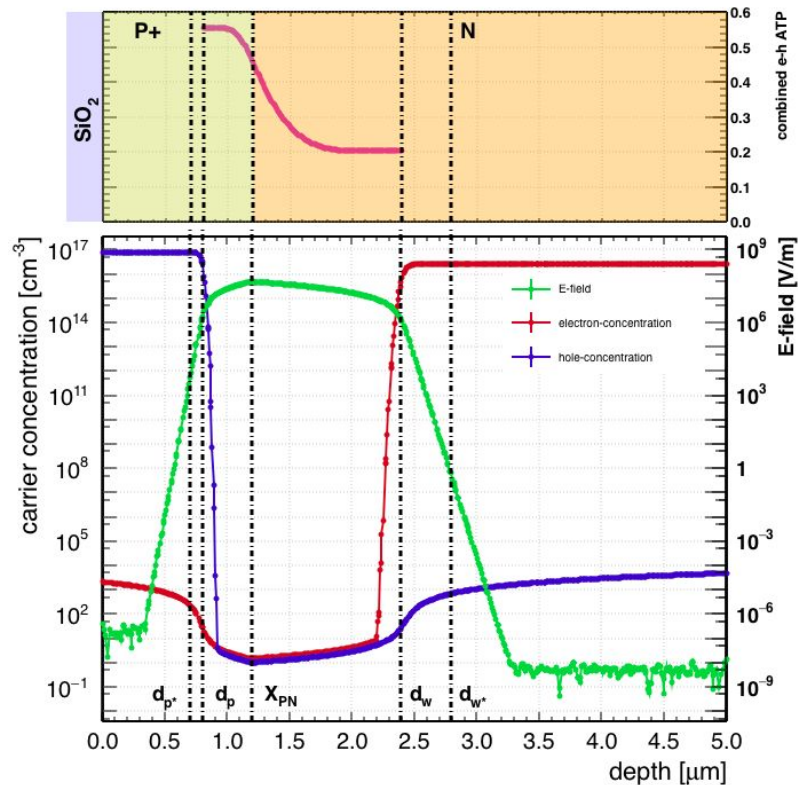
How Do SiPMs Work? Solid-State Approach

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This triggers an avalanche, with gain $\sim 10^6$ - 10^7 , which produces a readable signal.

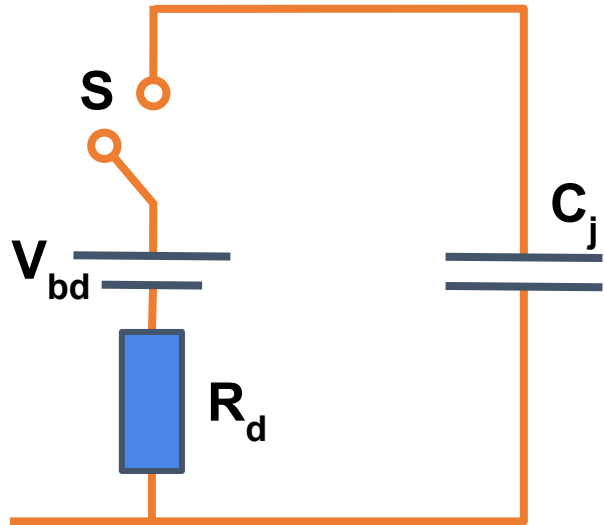


Single Micro-Cell



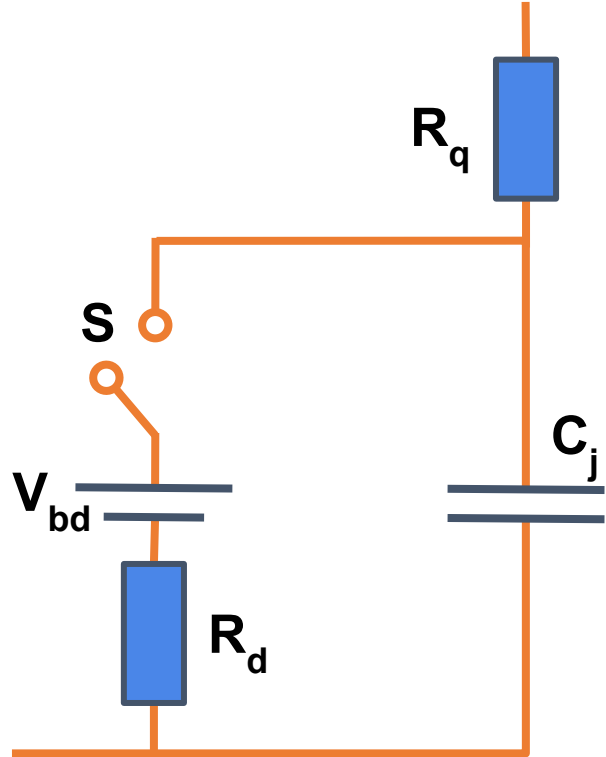
How Do SiPMs Work? Electronics Approach

20



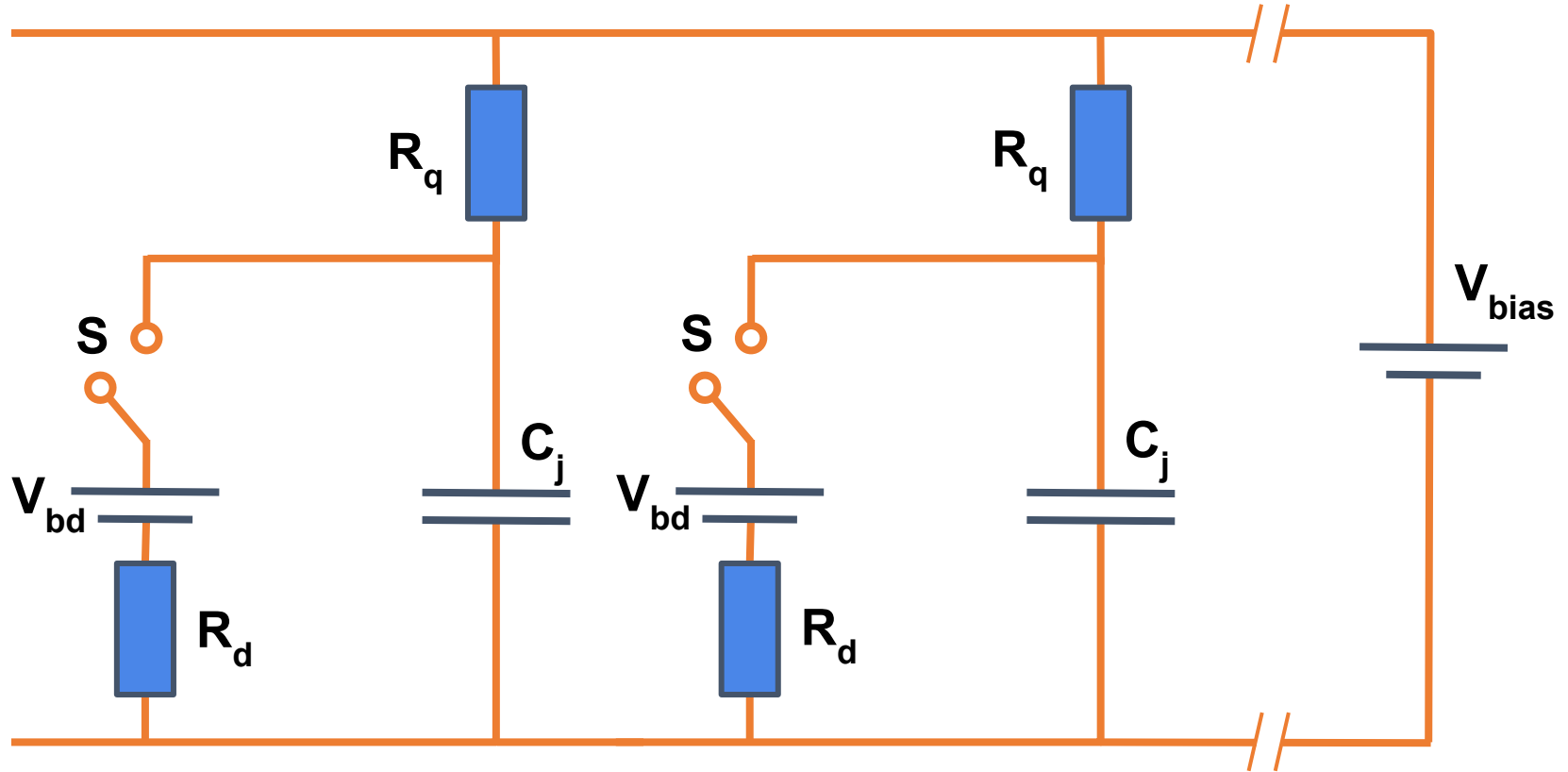
How Do SiPMs Work? Electronics Approach

21



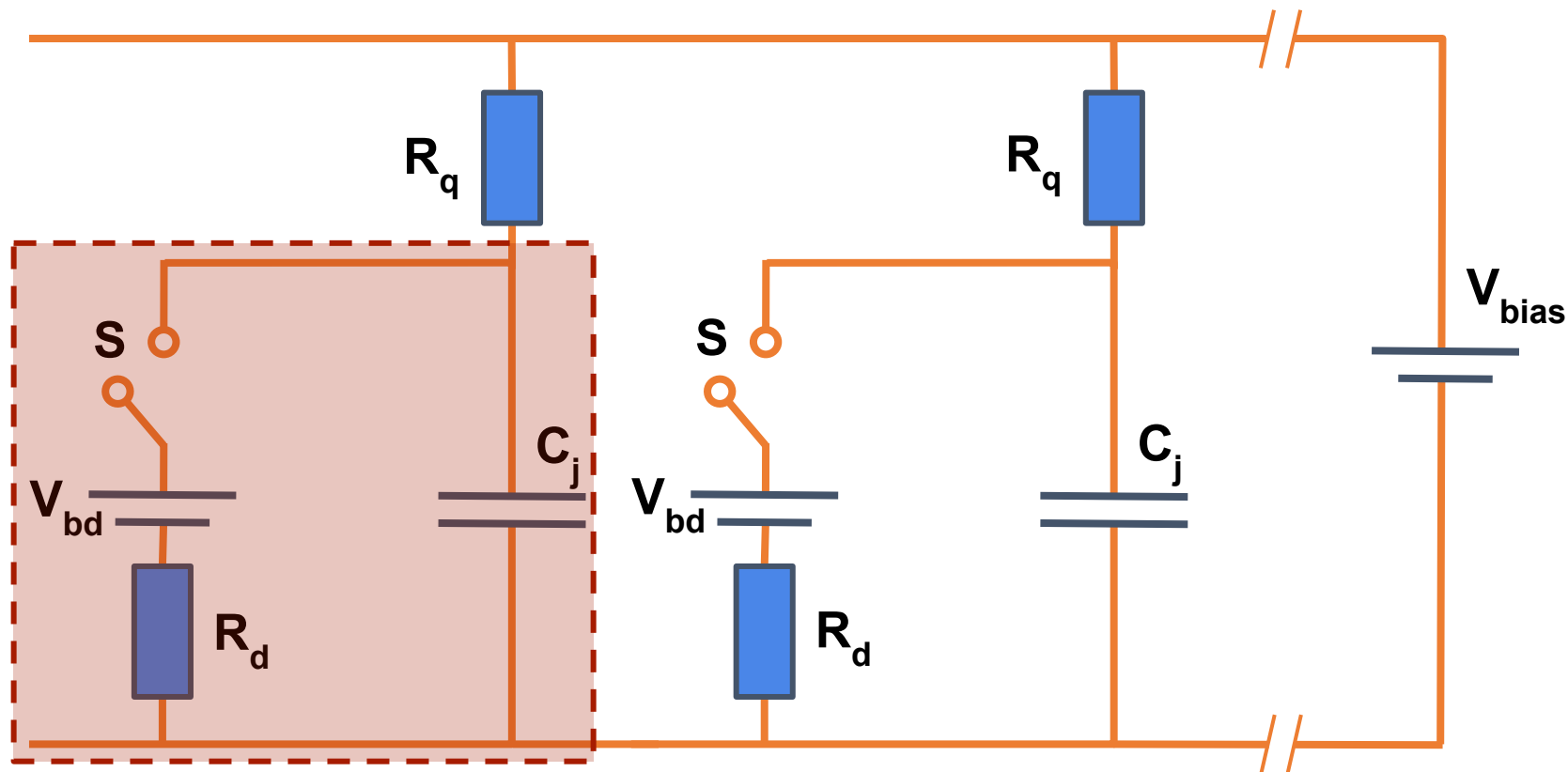
How Do SiPMs Work? Electronics Approach

22



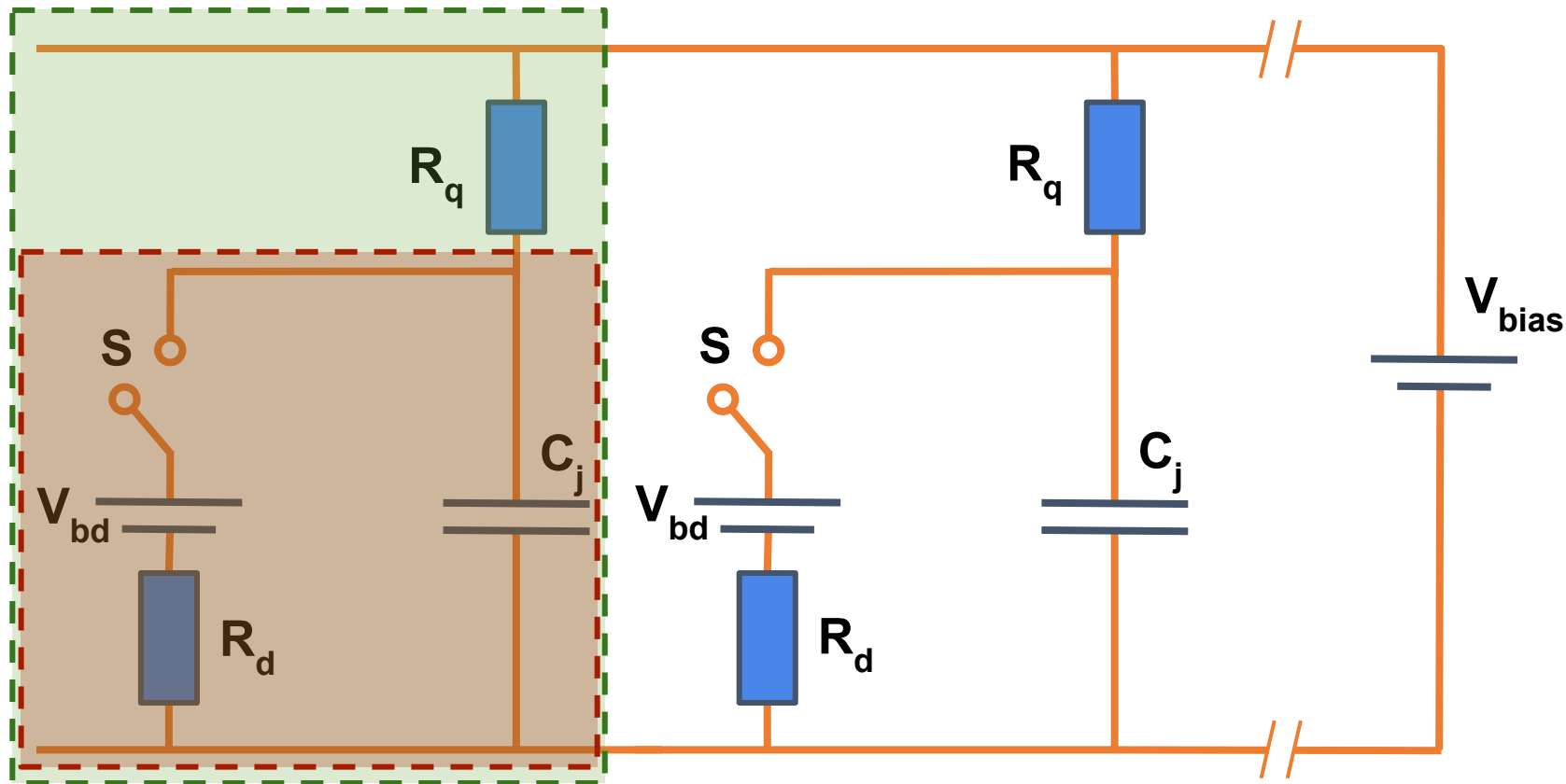
How Do SiPMs Work? Electronics Approach

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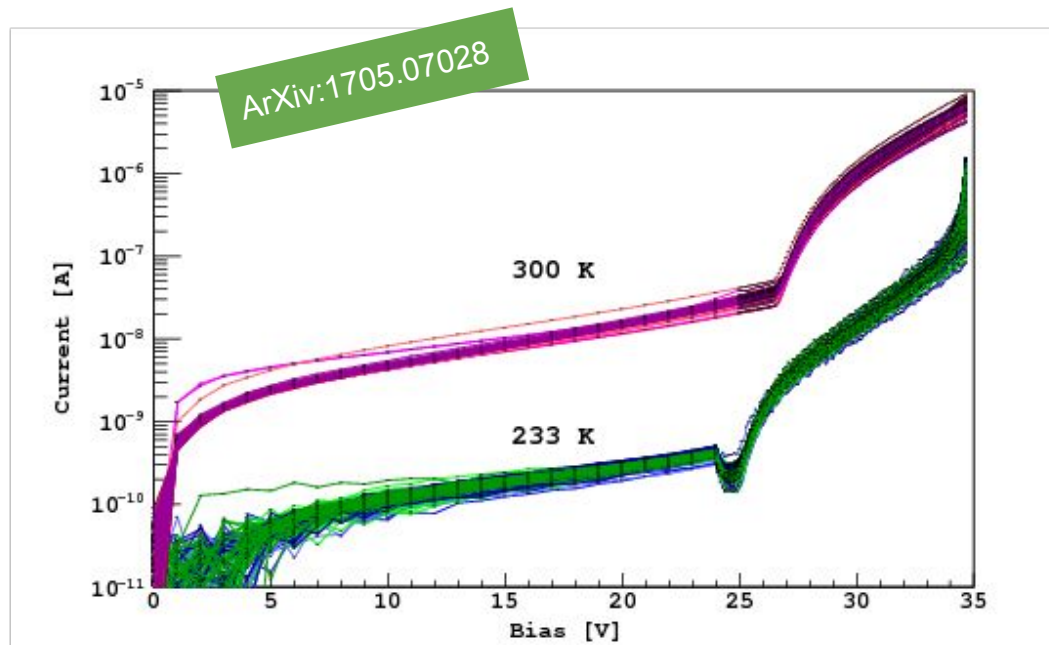
How Do SiPMs Work? Electronics Approach

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How Do SiPMs Work? Electronics Approach

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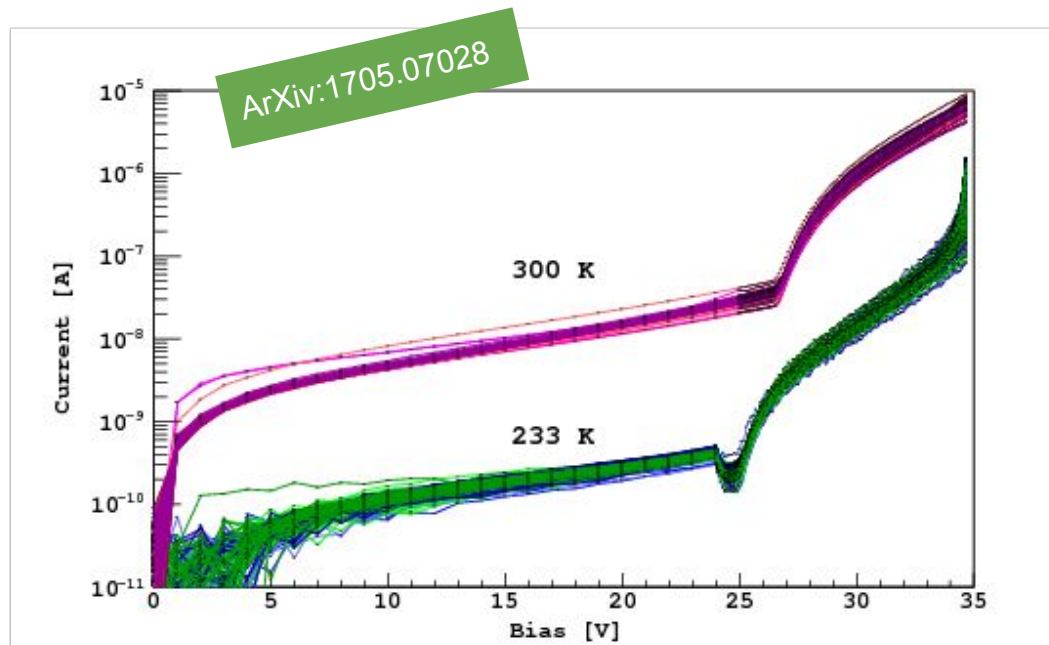


Linear Mode: Simple diode function, simply extract the generated carrier (e/h) after photon-absorption.

Linear

How Do SiPMs Work? Electronics Approach

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Linear Mode: Simple diode function, simply extract the generated carrier (e/h) after photon-absorption.

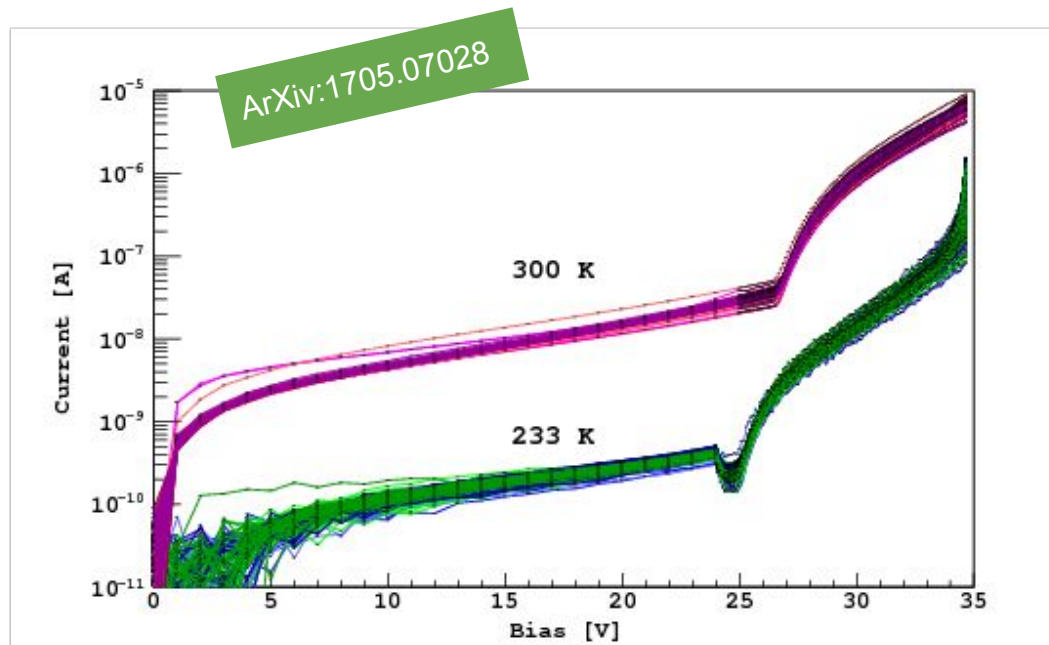
Proportional Mode: Simple Avalanche-Photo-Diode (APD), the generated carrier (e/h) undergoes gentle amplification (gain ~ 10 -100).

Linear

Proportional

How Do SiPMs Work? Electronics Approach

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Linear

Proportional

Geiger

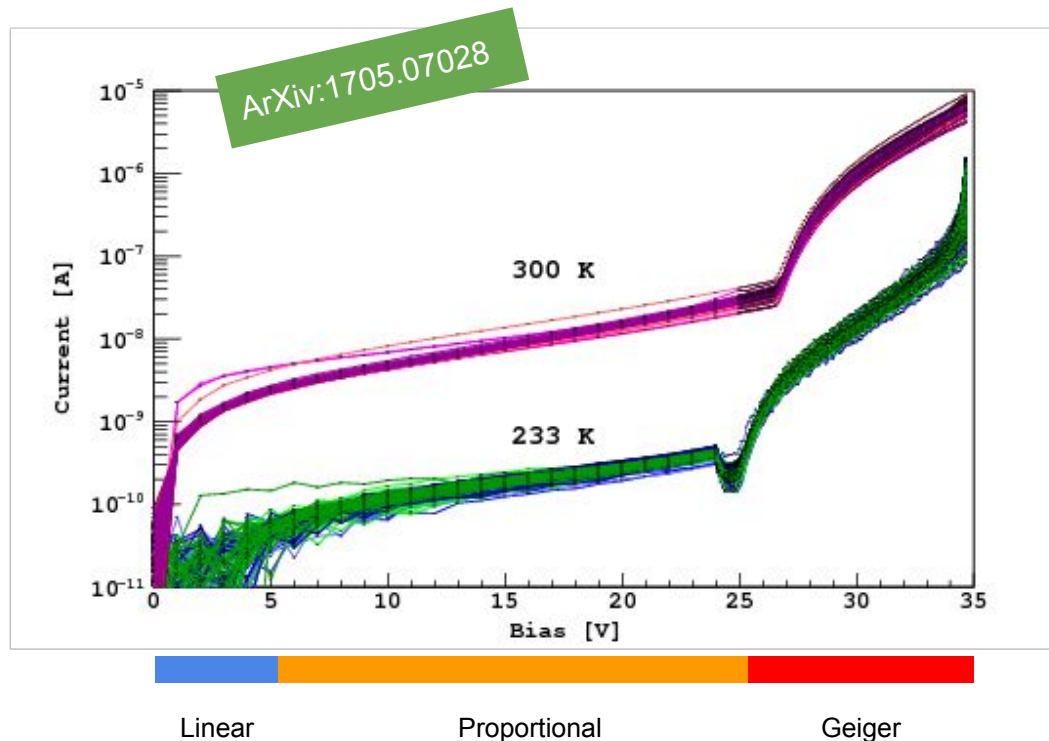
Linear Mode: Simple diode function, simply extract the generated carrier (e/h) after photon-absorption.

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Geiger Mode: SiPM range. Here the generated carrier (e/h) is subject to strong amplification (gain $\sim 10^6$ - 10^7).

How Do SiPMs Work? Electronics Approach

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Linear Mode: Simple diode function, simply extract the generated carrier (e/h) after photon-absorption.

Proportional Mode: Simple Avalanche-Photo-Diode (APD), the generated carrier (e/h) undergoes gentle amplification (gain ~ 10 -100).

Geiger Mode: SiPM range. Here the generated carrier (e/h) is subject to strong amplification (gain $\sim 10^6$ - 10^7).

Breakdown Voltage: Corresponds to the bias voltage value at which the device switches from Proportional to Geiger mode.

SiPM vs Other Photo-Sensor Techniques

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Technology	PMT	APD	SiPM
Gain	$10^6 - 10^7$	<100	$10^6 - 10^7$
Bias Voltage	~ 1200 V	~ 200 V	~ 50 V
Timing	Sub-ns	ns	Sub-ns (ps)
Photo Counting	Good	Good	Excellent
Temp Sensitivity	Low	High	Medium
Magnetic Fields	Shielding Needed	Immune	Immune
Warm Up Time	Required (min)	Instantaneous	Instantaneous
Ambient γ Exposure	Can Cause Damage	No Damage	No Damage

SiPM Challenges

- **Radiopurity:** Easy to make very radiogenically pure SiPMs, but very difficult to package them with equally pure encapsulation and substrates.
- **Size:** Currently individual SiPM vary in size from 1x1 mm to 12x12 mm and more, challenge is to scale up to m^2 (without being limited by noise effects).
- **Timing:** Current SiPM are somewhat limited by the recovery time (comparable to fast PMTs), innovative approaches could get push timing to few ps.
- **Noise:** At room temperature thermionic noise is still a limiting factor (reduced by several order of magnitudes at Cryogenics temperature). However, other correlated noise effect are also prominent in current SiPM.

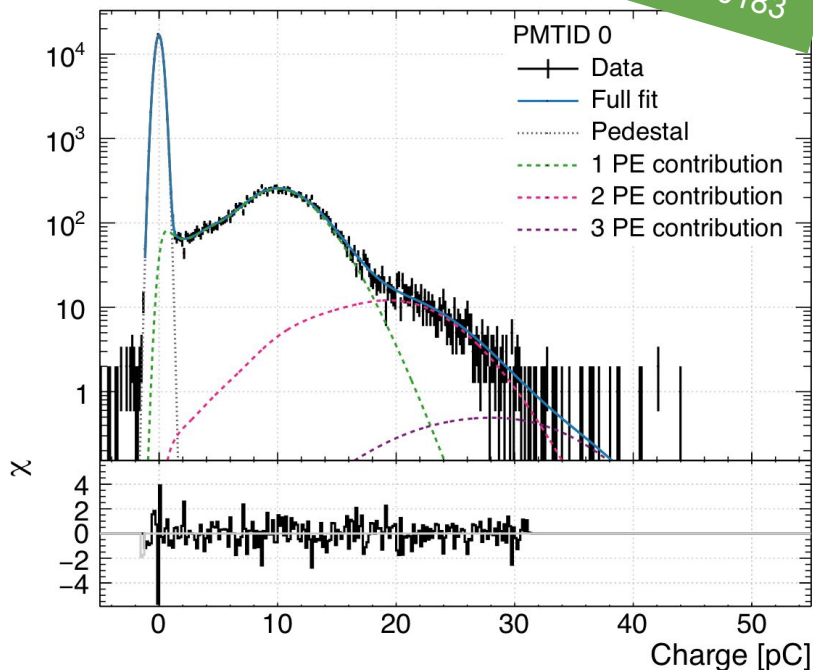
Characterization Model for SiPMs

Photon Counting Abilities

DEAP-3600 PMT:

Hamamatsu R5918 8" PMTs

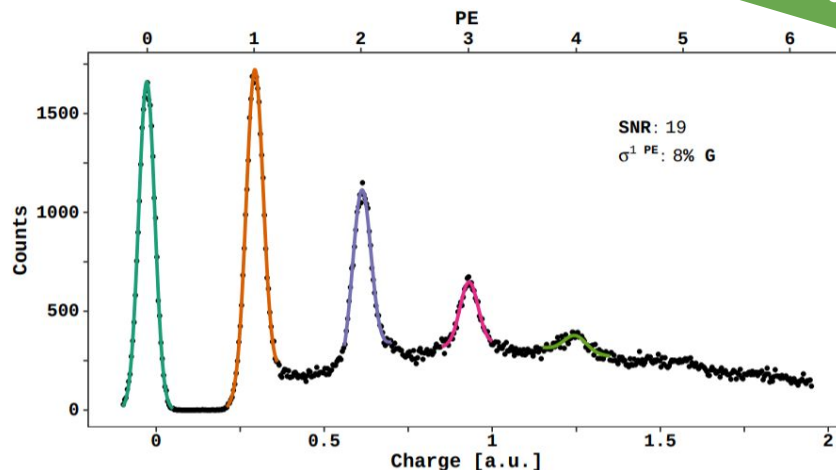
ArXiv:1705.10183



DarkSide-20k SiPM:

Fondazione Bruno Kessler 1x1 cm

ArXiv:1705.07028



Because of their discrete structure SiPM are outstanding photo-counters. Well separated single to multiple Photo-Electrons Peaks.

Output Signal and Pulse Shape

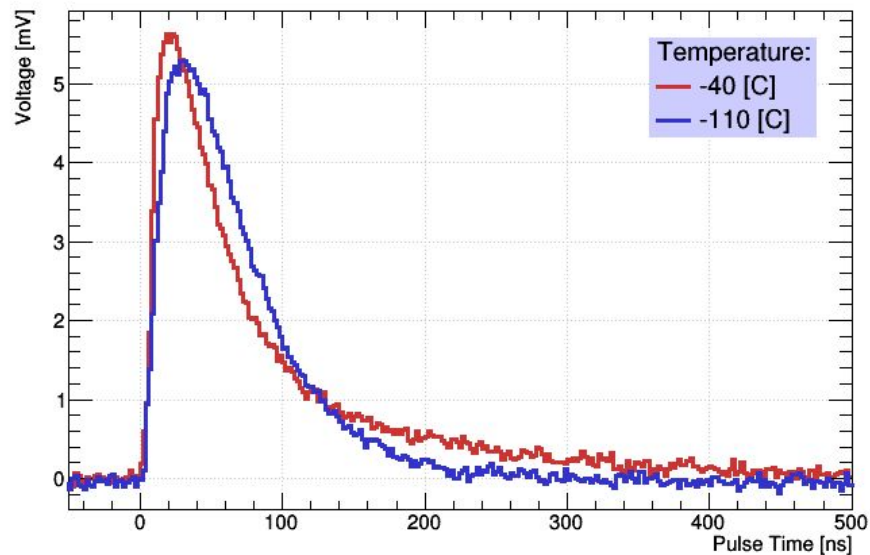
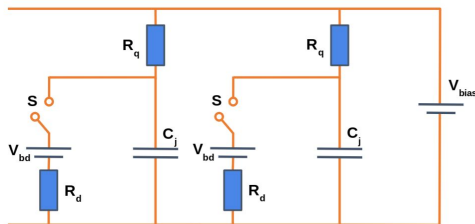
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Rise Time: $\tau_r \propto (R_d \cdot C_j)$

Parasitic Spike: $\tau_S \propto (R_{tot} \cdot C_{tot})$

Recovery Time: $\tau_L \propto (R_q \cdot C_j)$

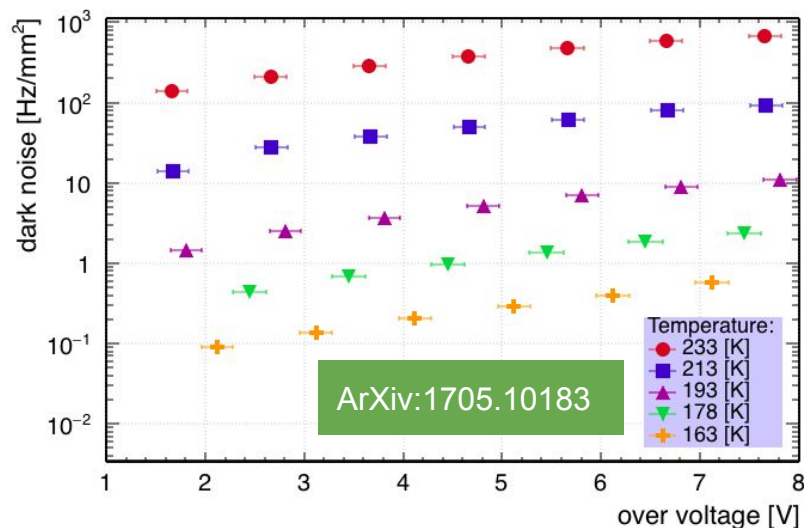
k: relative contribution of t_S and t_L .



$$V(t) = A \cdot \left[\left(\frac{1-k}{\tau_S} \right) \cdot \left(e^{-t/(\tau_S+\tau_r)} - e^{-t/\tau_r} \right) + \left(\frac{k}{\tau_L} \right) \cdot \left(e^{-t/(\tau_L+\tau_r)} - e^{-t/\tau_r} \right) \right]$$

SiPM Gain and Dark Noise

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Over Voltage = Bias V - Breakdown V

Example using Hamamatsu VUV4 SiPMs.

- Dark Noise pulses (DN) are charge signals generated by the formation of electron-hole pairs due to thermionic or field enhanced processes.
- Free carrier will undergo the standard avalanche process.
- Temperature dependent.
- Bias voltage dependent.
- DN Rate ~ 0.1 [Hz/mm²] at LXe Temperatures (163 [K]).

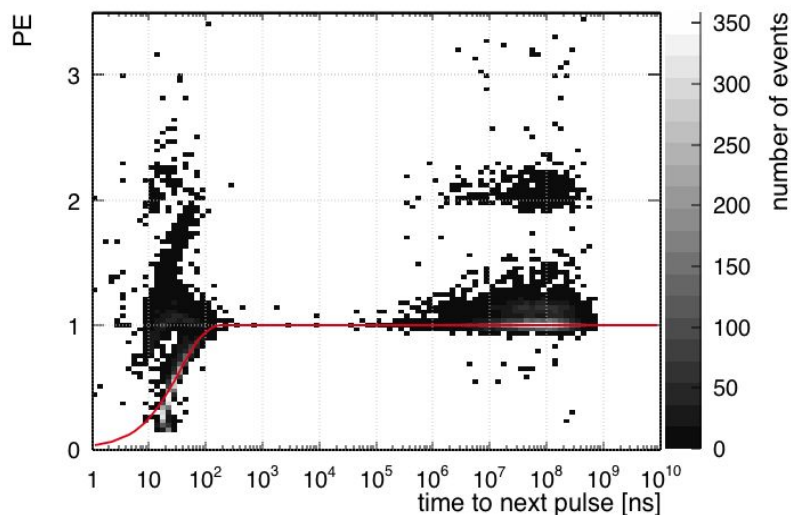
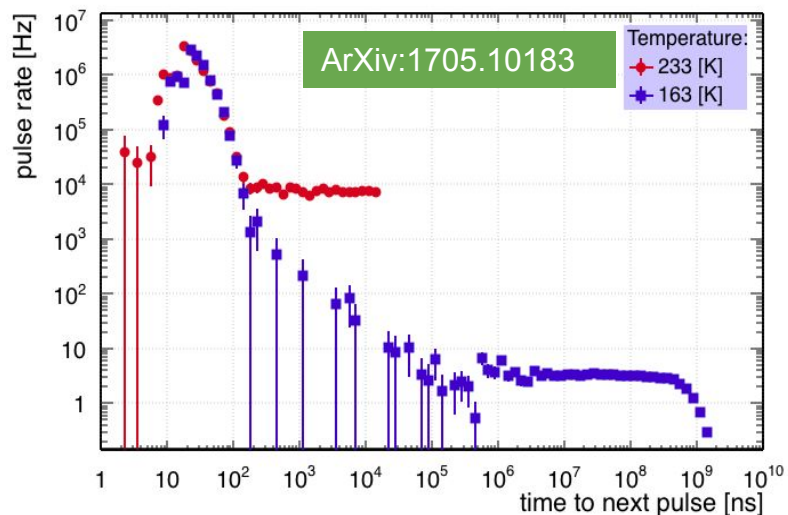
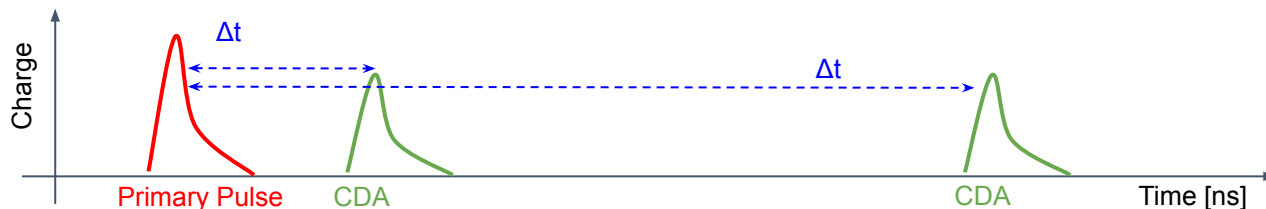
Correlated Avalanches Noise

Correlated Avalanche noise is due to at least two processes:

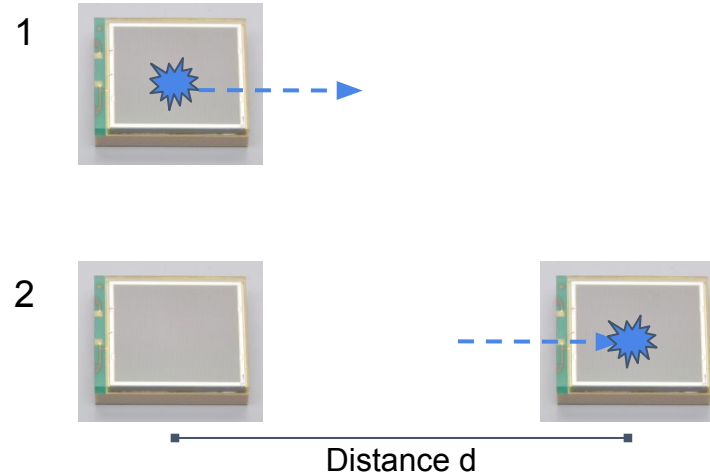
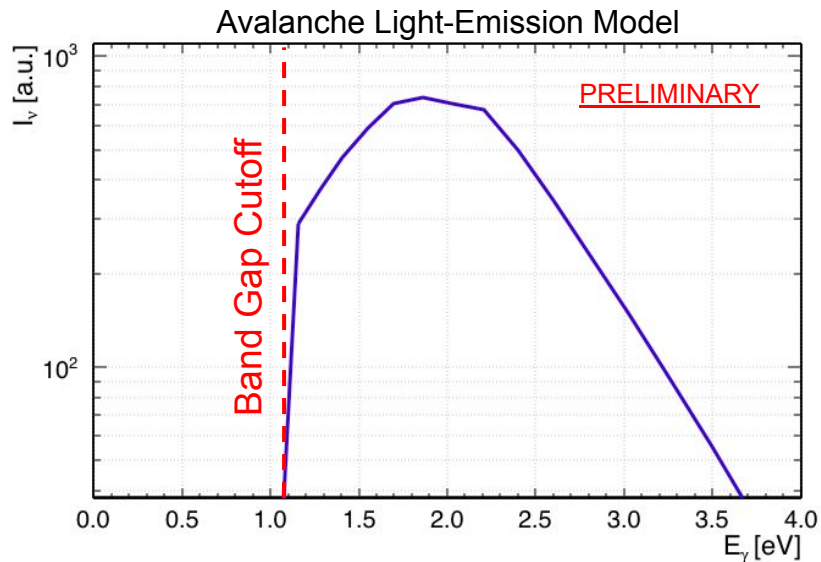
1. **Correlated Delayed Avalanches:** Trapping and subsequent release of charge carriers produced in avalanches (similar to the PMTs after-pulsing effect).
2. **Cross-Talk:** Production of secondary photons during the avalanche in the gain amplification stage detected in nearby cells or reflected back to the original cell for a secondary avalanche.

Correlated Delayed Avalanches (CDAs)

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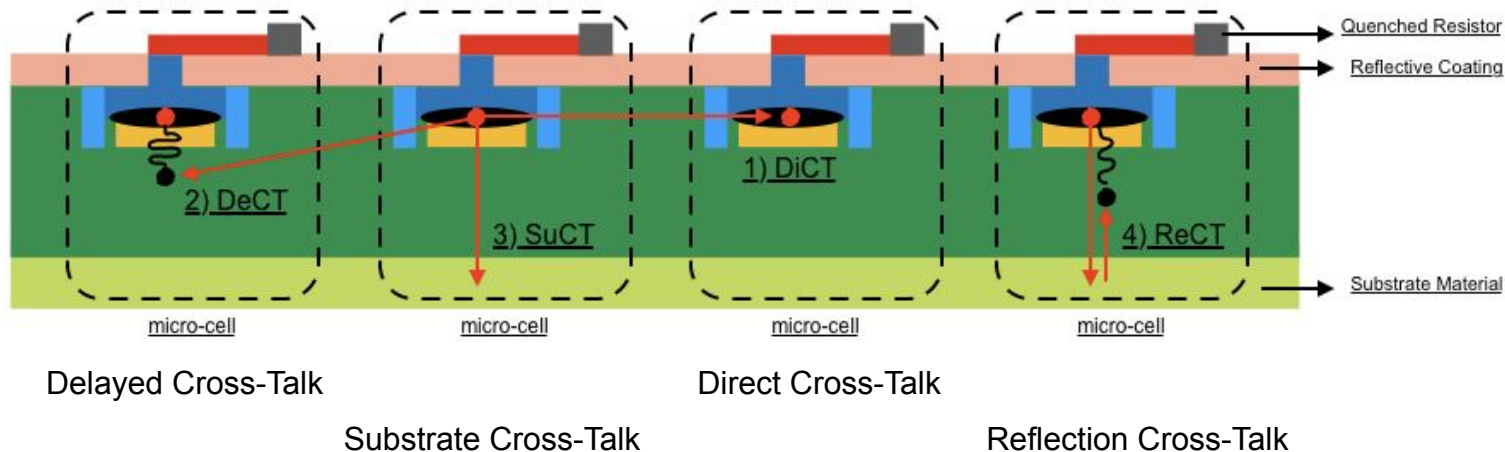
The carrier induced avalanche in the depleted region reaches high enough temperature to create a quasi-plasma, which can emit photons in a broad spectrum (Interband transition and bremsstrahlung radiation). The emitted radiation can reach and be detected a nearby SiPM.



Cross-Talk Effect

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There are different types of Cross-Talk and they are heavily dependent on the structure of the micro-cell. Overall all there are four type of internal Cross-Talk: Delayed Cross-Talk, Substrate Cross-Talk, Direct Cross-Talk, Reflection Cross-Talk.



Cross-Talk Effect

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Different devices with different optical trenches and different substrate have very different Cross-Talk behaviour. Example with Hamamatsu VUV4 (Left) and FBK-RGB (Right).

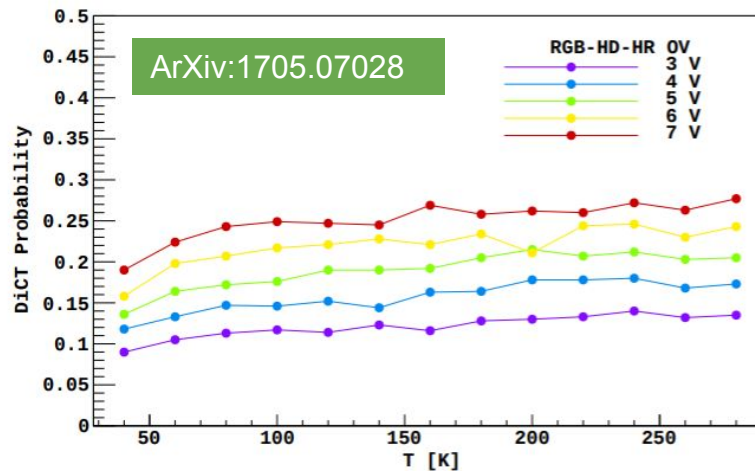
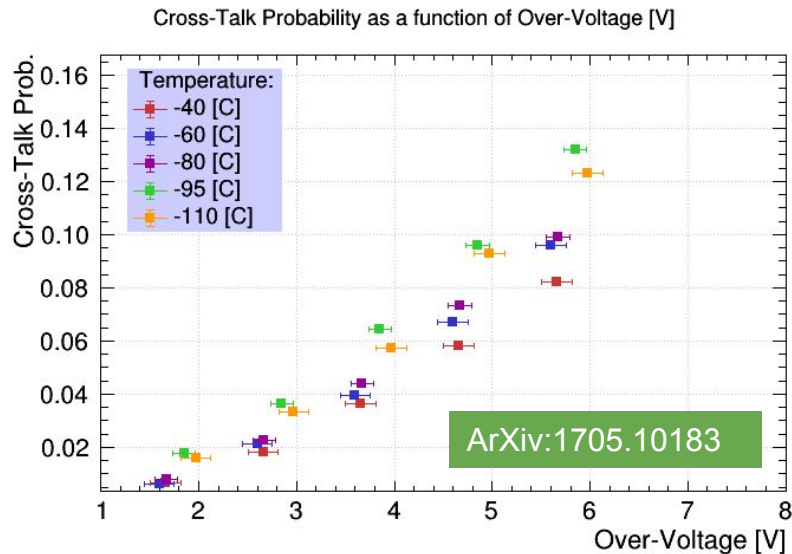
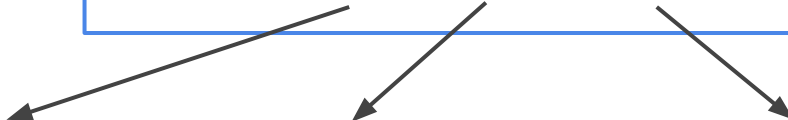


Photo-Detection-Efficiency

In general the Photo-Detection-Efficiency (PDE) is defined as the probability of a given photon (of a given wavelength) to be detected and produce a measurable signal in the SiPM.

Relative PDE measurements are “easy”, however, absolute PDE measurements are tricky.

In detail PDE depends not only on the device properties but also on the inpinning photon.
A more accurate definition of PDE can be given as the following:

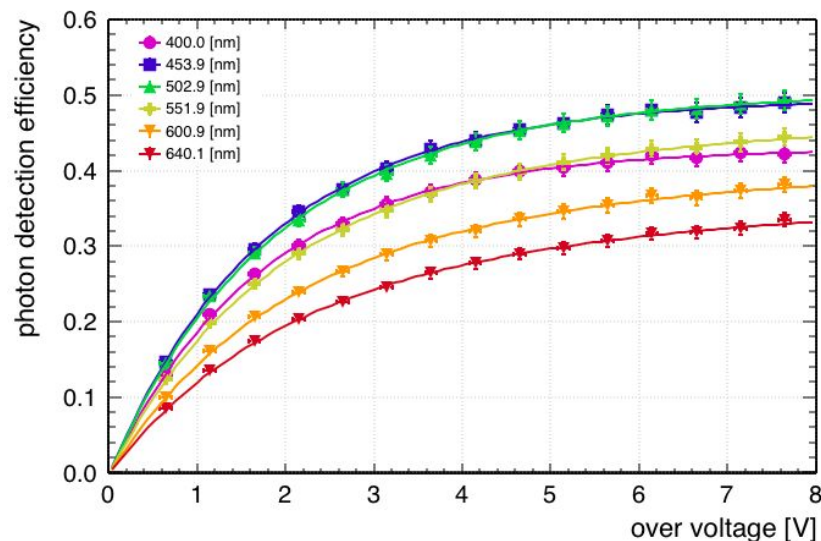
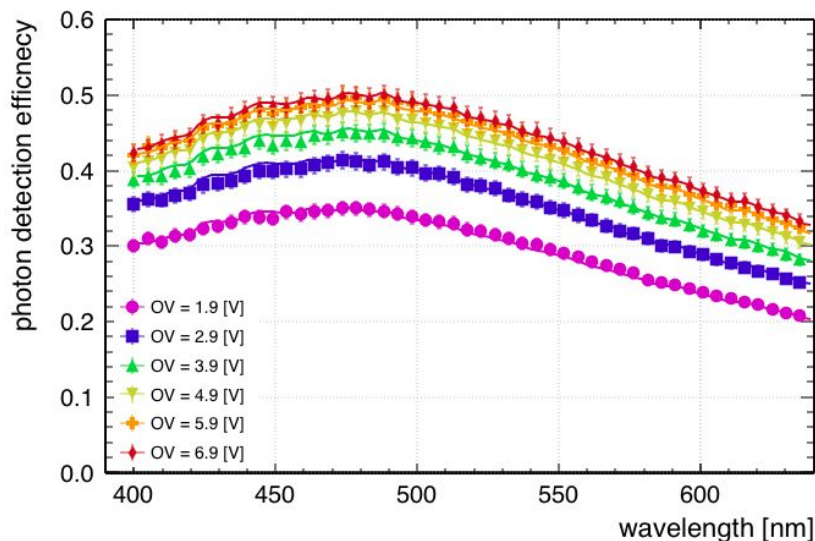
$$PDE = FF \cdot \epsilon(\lambda) \cdot P_p(V, \lambda)$$


Fill-Factor Si Quantum Efficiency Avalanche-Triggering-Probability

Photo-Detection-Efficiency

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As anticipated the PDE is dependent on the wavelength of the incoming photon and also on the bias voltage of the device. However, after a certain V value the PDE saturated (PDE_{max}).



Avalanche Triggering Probability

PDE needs to account for the fact that if the photon is absorbed outside of the active region, it will not be observed.

$$PDE = \epsilon_0 \cdot \int_{d_P^*}^{d_W^*} \frac{1}{\mu} \exp\left(-\frac{x}{\mu}\right) \cdot P_P(x, V) dx$$

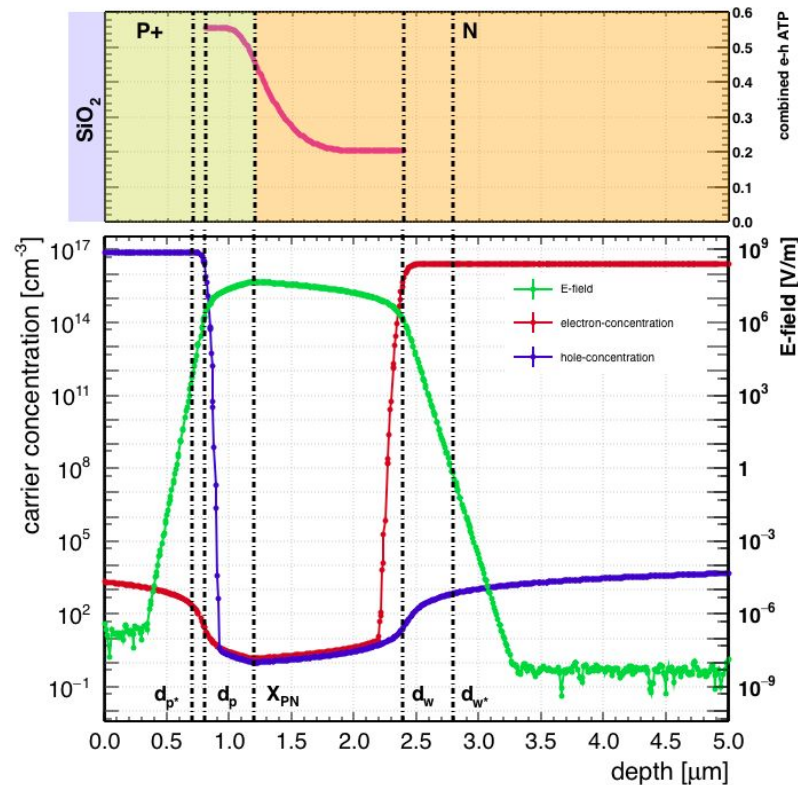
The Total Avalanche Triggering Probability has both an electron-driven and a hole-driven component

$$P_P(x, V) \equiv (P_e(x, V) + P_h(x, V) - P_e(x, V) \cdot P_h(x, V))$$

The fraction of electron-driven avalanches can be expressed as the following (depends on the size of the active region):

$$f_e^* \equiv \left[\frac{1 - \exp\left(-\frac{(x_{PN} - d_P^*)}{\mu}\right)}{1 - \exp\left(-\frac{W^*}{\mu}\right)} \right] \in [0 - 1]$$

ArXiv:1904.05977



Avalanche Triggering Probability

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ArXiv:1904.05977

Redefine PDE to include the avalanche triggering probabilities for electron and hole driven avalanches, and to include the PDE_{\max} factor.

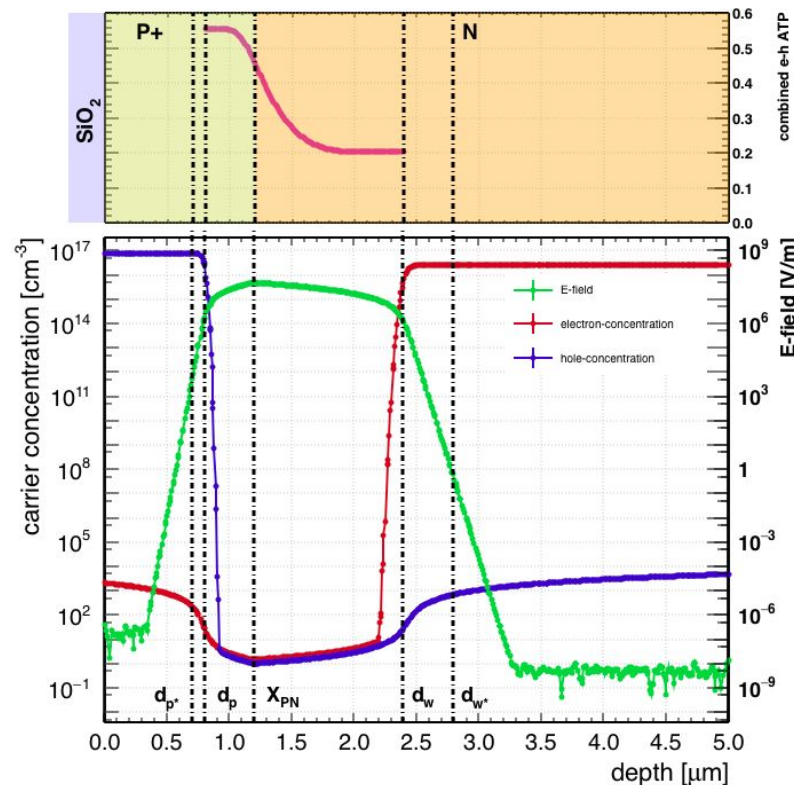
$$PDE = PDE_{\max} \cdot \left(P_e(d_P) \cdot f_e^* + P_h(d_W) \cdot (1 - f_e^*) \right)$$

The probability to have an electron-driven avalanche is dependent on the size of the p+ active area.

$$P_e(d_P) = \left[1 - \left(k_e \cdot V \cdot \exp \left(-k_{e2}/\sqrt{V} \right) \right)^{-2} \right]$$

The probability to undergo a hole-driven avalanche is dependent on $P_e(d_p)$ and the field-strength factor in the junction k.

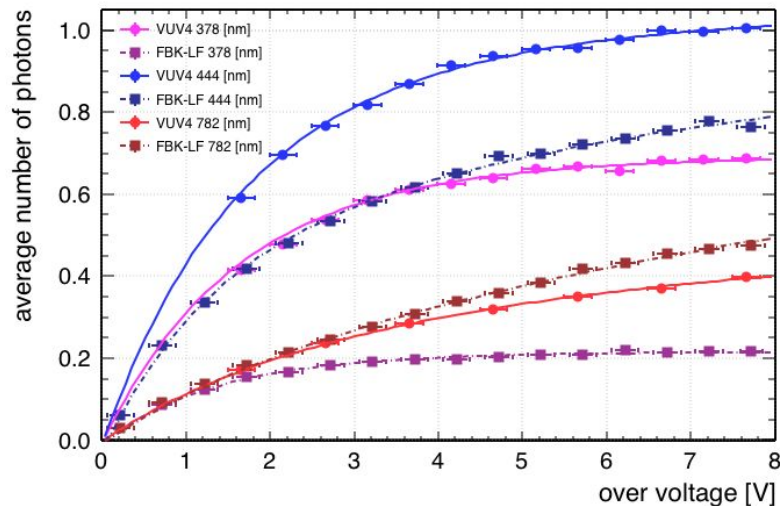
$$P_h(d_W) = \left[1 - \left(1 - P_e(d_P) \right)^k \right]$$



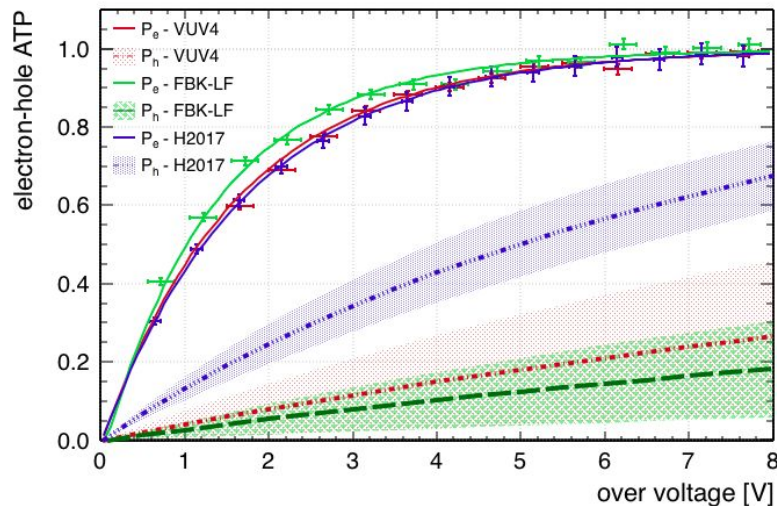
Avalanche Triggering Probability

This new characterization model was fully tested with multiple devices and at multiple wavelengths, with strong agreement across the full spectrum.

ArXiv:1904.05977



$$P_e(d_P) = \left[1 - \left(k_e \cdot V \cdot \exp \left(-k_{e2}/\sqrt{V} \right) \right)^{-2} \right]$$



$$P_h(d_W) = \left[1 - \left(1 - P_e(d_P) \right)^k \right]$$

Development of 3DSiPM

Why Digital Integration?

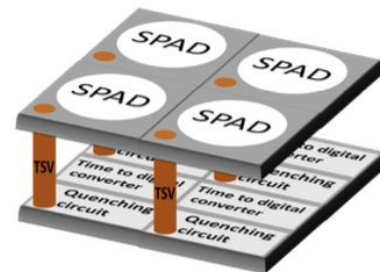
46

- Single Photon Avalanche Diodes (SPADs) are the basic unit cell of analog and digital SiPMs.
- But SPADs are effectively Boolean detectors, digital information is available at the sensor level.
- Analog SiPM sum boolean detectors (SPAD arrays) to get linear response [SPAD to Transimpedance Amplifier to ADC]

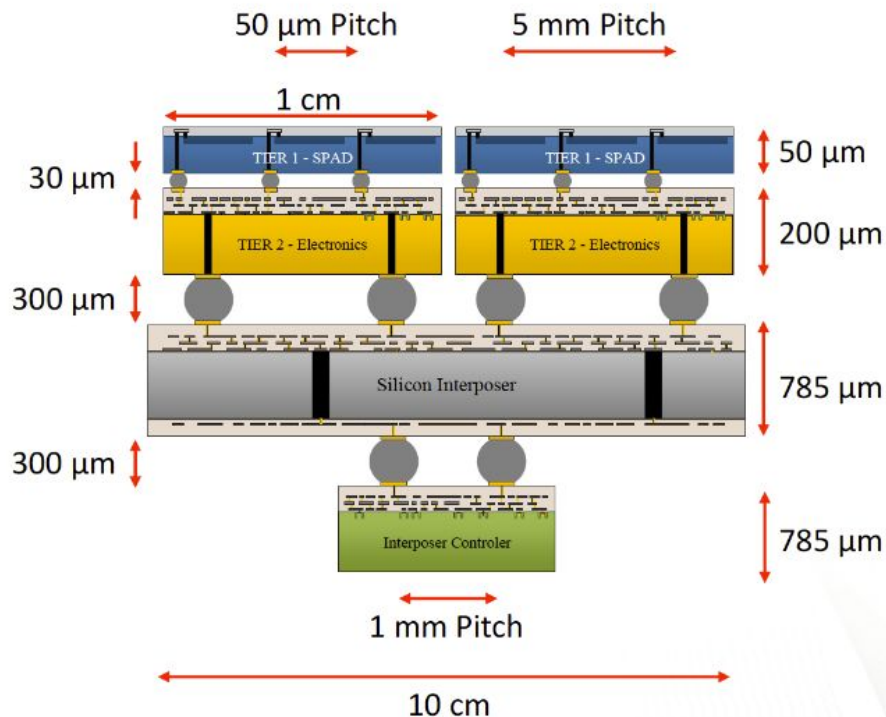
To Digitize the data AGAIN!

3D integration to fully take advantage of the SPAD's digital nature:

- Independent optimization of detector layer and readout electronics
- One-to-one coupling minimizes digitization power, allows for CA noise mitigation, enabling/disabling cells
- One-to-one coupling between the SPAD and the Quenching circuit with uniform routing
- One-to-one coupling provides greater immunity to process, voltage and temperature variations and picoseconds timing Time-to-digital converter per pixel

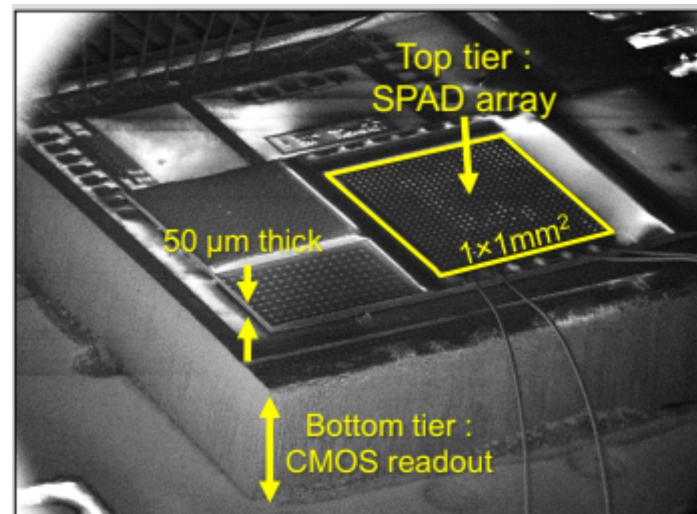


SiPM Digital Integration



S. Charlebois, CPAD 2018,
"3D Digital SiPM Development for Large Area
Photodetectors"

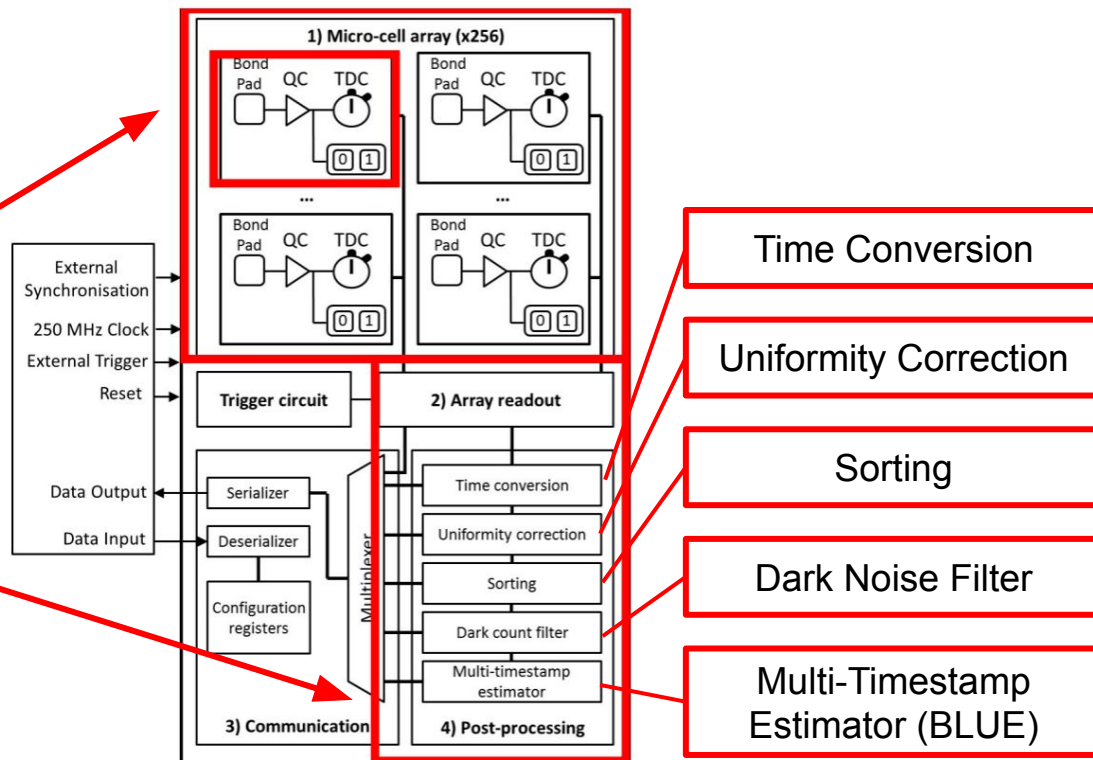
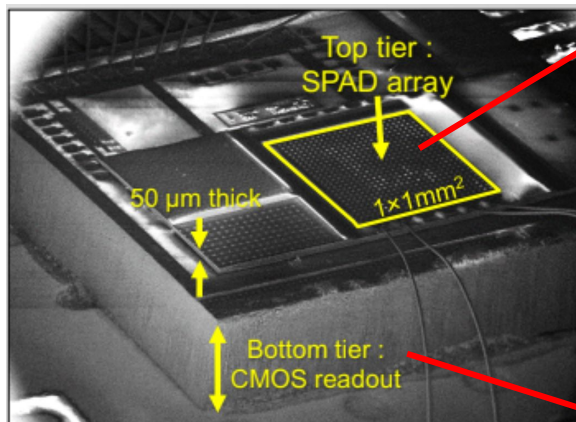
47



- Time-to-digital converter per pixel.
- No compromise between electronics and SPAD processes. Great photosensitive fill factor.
- Time Resolution 50-10 ps.

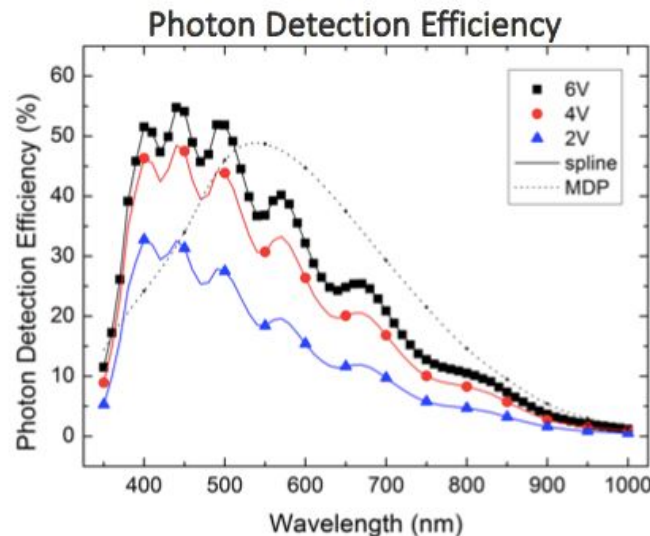
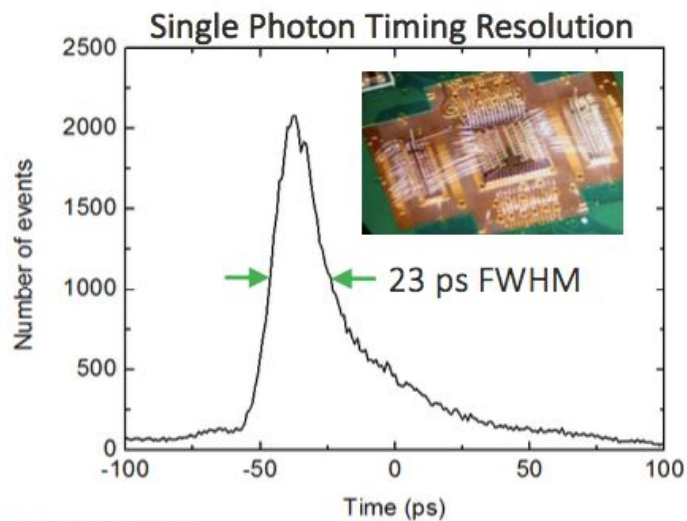
Digital Signal Processing

48



PRELIMINARY Results from first Production

49



400-500 nm range :

- fast scintillators for PET scanners

VUV range (< 200nm):

- liquid Xe : 178 nm
- liquid Ar : 128 nm

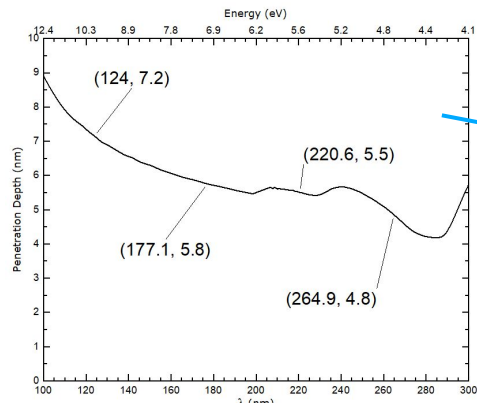
Very promising PRELIMINARY results from first production batch at the University of Sherbrooke (Quebec Canada). ~23 ps timing with standard CMOS integration (plenty of room for improvement)

Boosting SiPM VUV Efficiency

Boosting SiPM VUV Efficiency

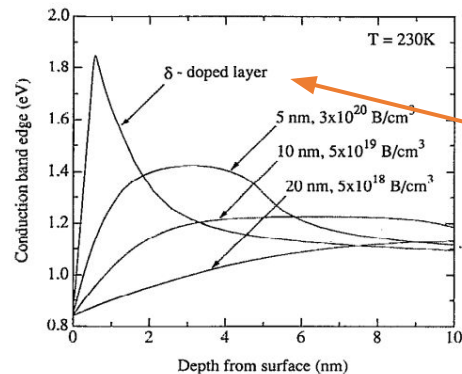
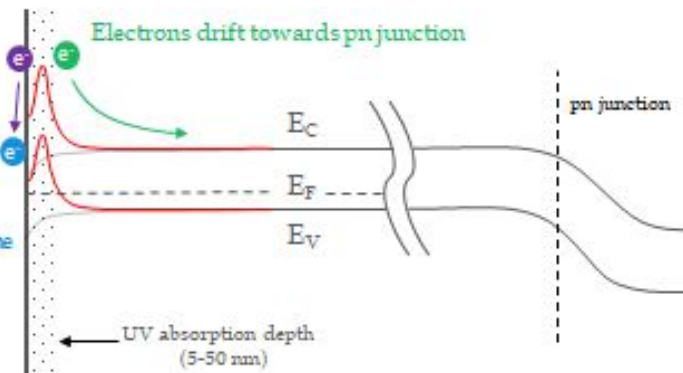
51

Penetration Depth Challenge



Only electrons absorbed too close to the surface get lost

Electrons in interface states are trapped at the surface
→ reduce dark noise



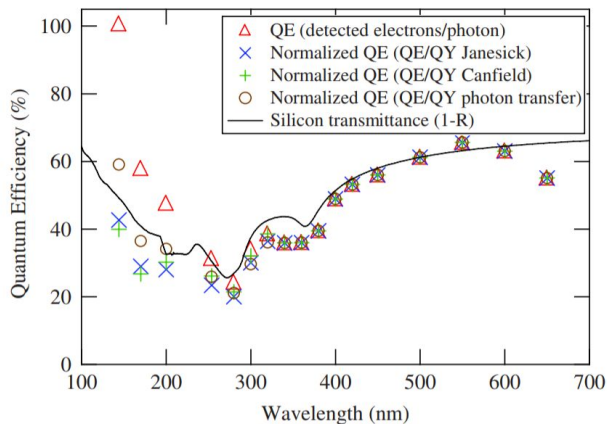
The delta-doping concept: Introduce an highly-doped layer at the surface of the SiPM, to modify the energy band profile. Electron generated below this barrier are drifted towards the p-n junction. Charges captured on the surface defects and can not contribute to the device noise levels [1].

[1] App. Phys. Lett. 61, 1084 (1992) doi:10.1063/1.107675

Boosting SiPM VUV Efficiency

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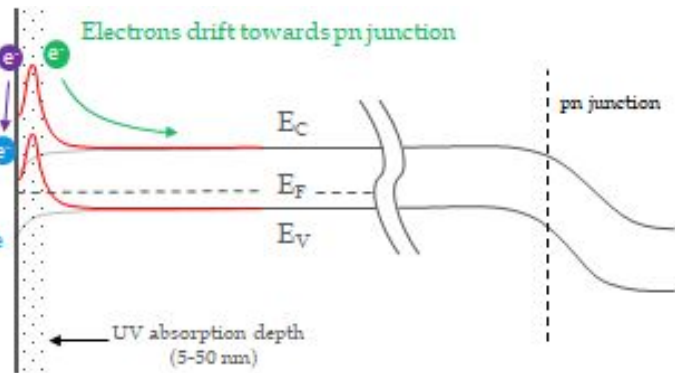
Previously demonstrated in CCD



Applied Optics, vol. 51, issue 3, p. 365

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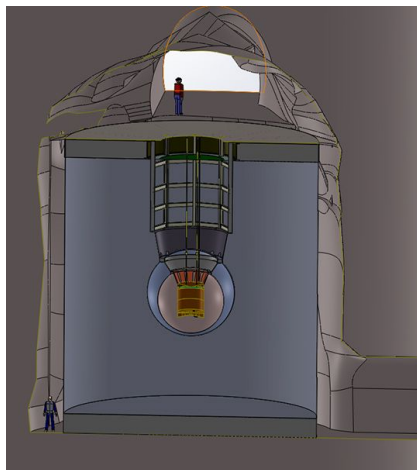
Precision-Physics Applications

Precision-Physics Applications

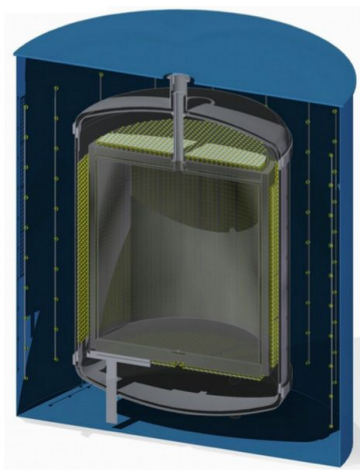
54

Ultimate Goal: >50% PDE(VUV) 3DSiPM

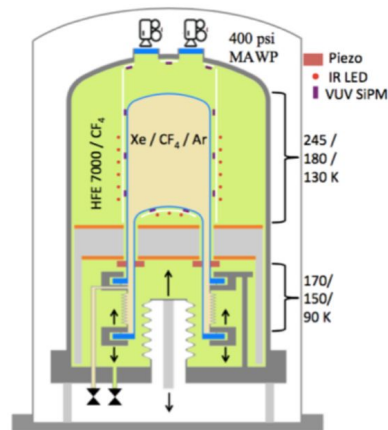
This work is primarily targeted towards low-background liquid noble experiments (Dark Matter & Neutrino) and precision measurements of ultra-cold neutrons (UCNs) properties like the nEDM.



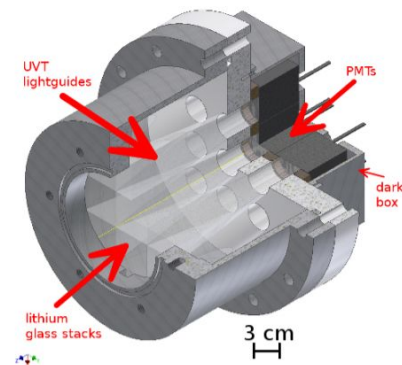
nEXO Experiment



300T Single-Phase LAr



LAr Bubble Chamber



Ultra-Cold Neutrons

Commercial Applications

Commercial Applications

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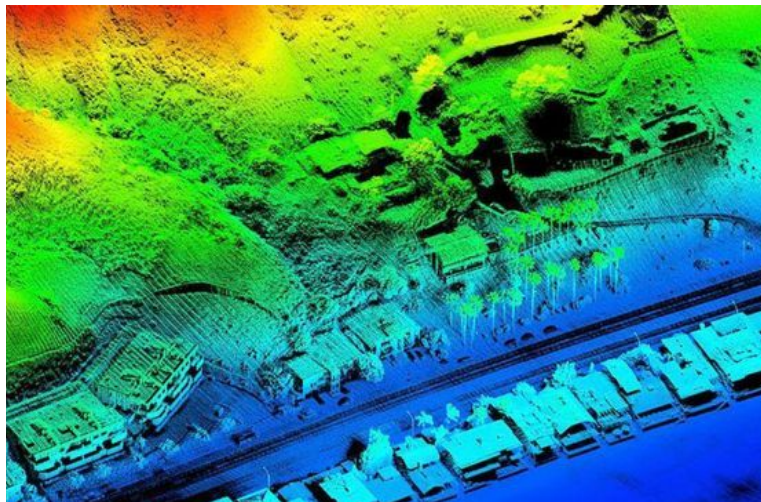
LXe PET Scanner (Medical Imaging)

LabPET/CT (2015)



Challenge: Pulse Timing < 15 [ps]

LiDAR Sensors with SiPM (3D Imaging)



Challenge: Good PDE (>30%) from 200-800 [nm]

Early-Fire Gas Analyzer: Use both Visible and UV light for particlets studies in area where fires are a considerable yearly problem (west-coast US, Canada).

Conclusions

Conclusions

- New technologies and ideas are fundamental for precision physics to search beyond the standard model of particle physics.
- SiPMs already provide a great option (compared to PMTs) for experiments dominated by scintillation and Cherenkov light detection.
- Analog SiPMs challenges include: size scalability, radiopurity, picoseconds timing, overall noise reduction.
- We have introduced a novel physics-driven method to characterize and fully understand SiPMs, including avalanche-triggering-probability ([ArXiv:1904.05977](https://arxiv.org/abs/1904.05977)).
- Described the progress on 3DSiPM and shown promising early results (timing ~23 ps).
- Introduced a new technique for boosting VUV efficiency via delta-doping.
- An ultimate device with electronics integration (3DSiPM) and boosted VUV sensitivity will be a game changer for multiple precision-physics experiments and multiple commercial applications.

Thank you
Merci

www.triumf.ca

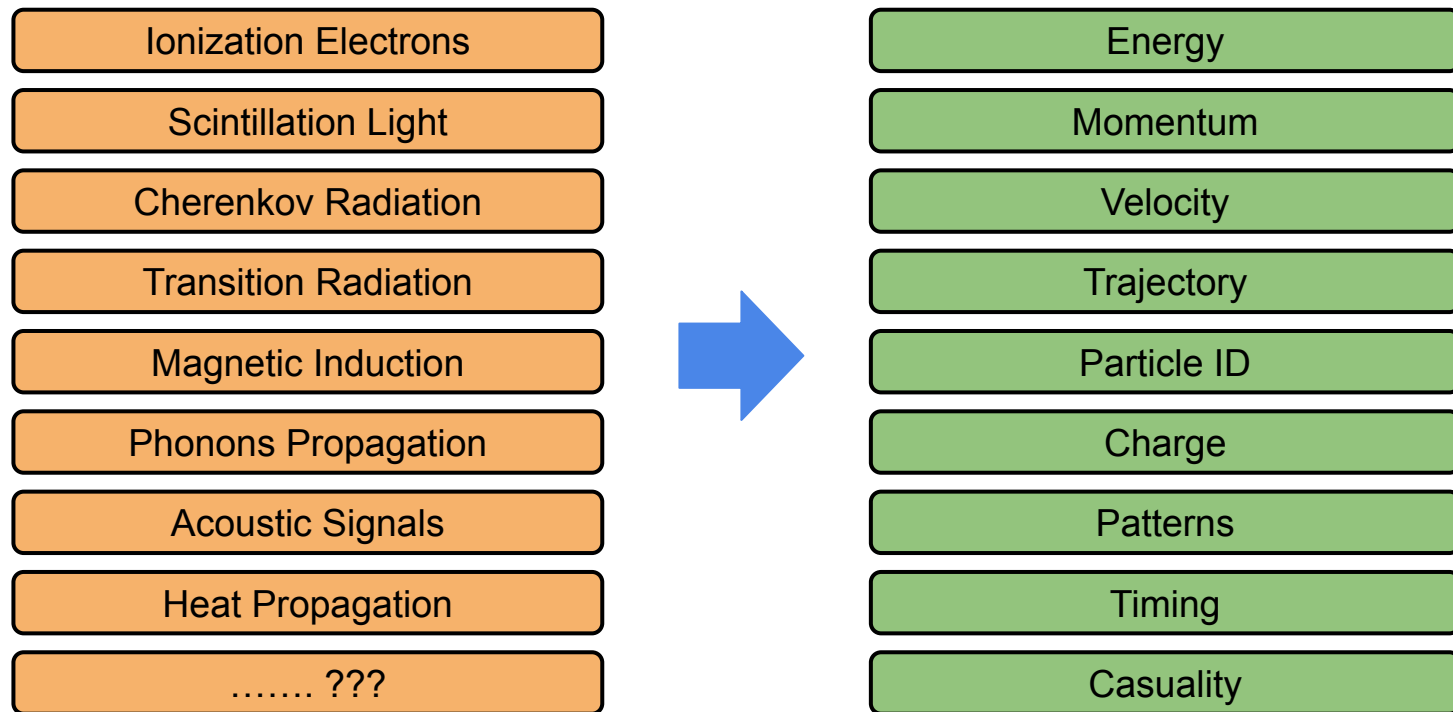
Follow us @TRIUMFLab



Backup Slides

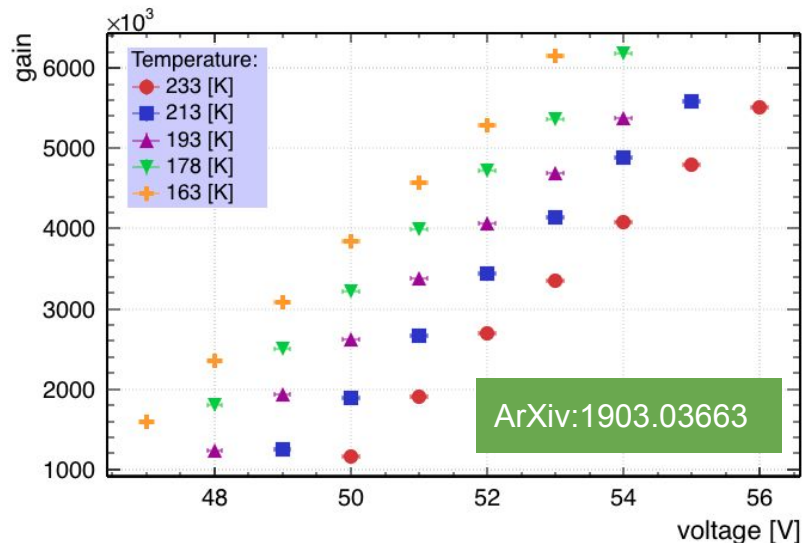
From Technology Signals to Physical Information

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SiPM Gain and Dark Noise

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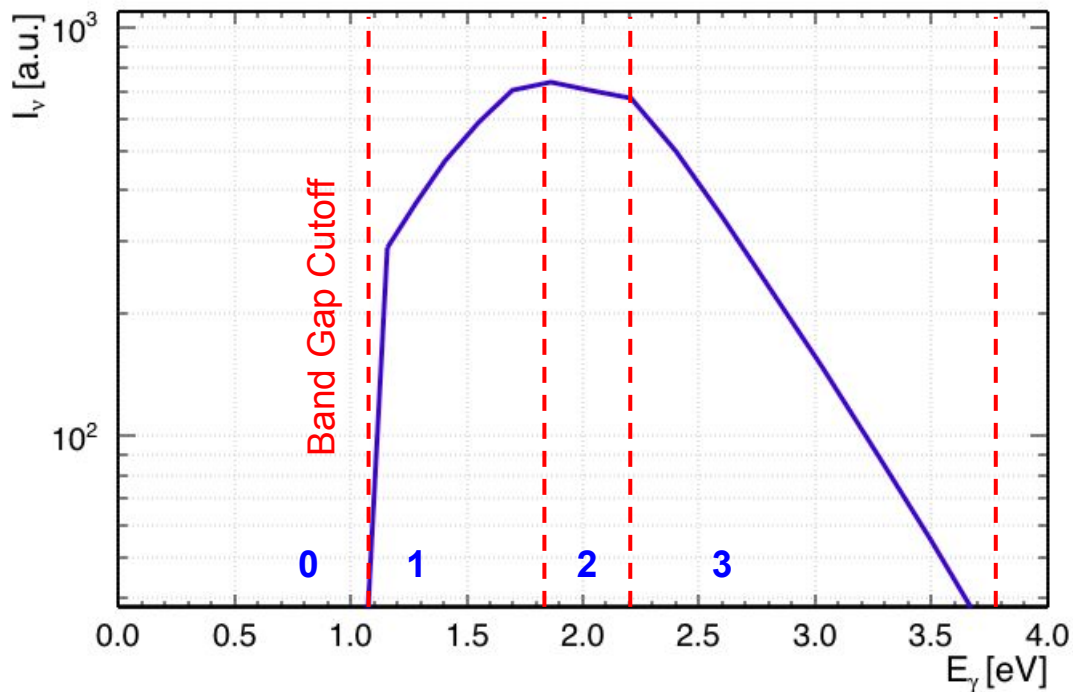
Example using Hamamatsu VUV4 SiPMs.
The SiPM Gain can be defined as the following:

$$G = \left(\frac{I_{dr}}{2^{14}} \right) \cdot \left(\frac{\langle A_{1PE} \rangle \cdot 10^9}{q_e \cdot g_{amp} \cdot R} \right)$$

I_{dr} = Input Dynamic Range of Digitizer
 $\langle A_{1PE} \rangle$ = Average 1PE Pulse Integral
 R = Amplifier load resistance
 g_{amp} = SiPM amplifier gain
 q_e = electron charge.

Physical Model for Light Emission

IEEE, DOI: 10.1109/16.760412



(Example using arbitrary values)
The model is divided in the following four components:

[0] Band-gap cutoff, 1.14 eV for Si at 330 [K]. Temperature dependent.

[1] Interband transitions of hot holes between different mass valence bands (phonon-assisted).

[2] Bremsstrahlung radiation by hot electron scatters.

[3] Direct-interband electron/hole transitions.

Physical Model for Light Emission

$$I_{di}(E_\gamma) = A \cdot E_\gamma^2 \cdot \left(\sqrt{E_\gamma - E_g} \right) \cdot \exp \left(-\frac{E_\gamma}{W} \right) \cdot \left(1 + \frac{r_E E_\gamma}{W} \right)$$

$$I_{di}(E_\gamma) = B \cdot \exp \left(-\frac{E_\gamma}{k_0 T_e} \right)$$

$$I_{ib}(\nu) = C \cdot E_\gamma^{(3.5-a^*)} \cdot \exp(-b \cdot (1.41 \cdot E_\gamma - E_g))$$

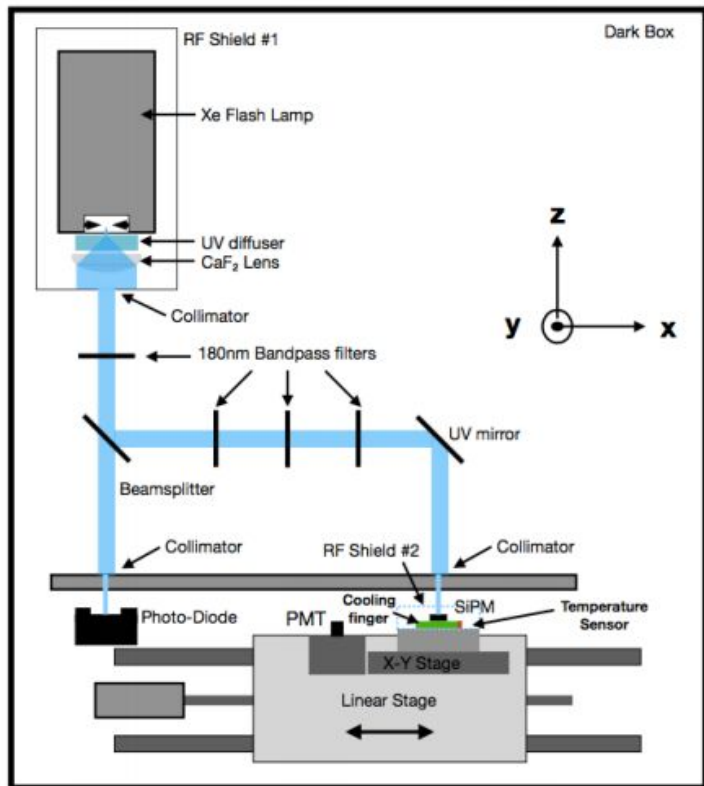
$$a^* = (1 - 3/\alpha)/(2 + 3/\alpha)$$

- **A, B, C** = Scaling factors
- **E_γ** = Photon Energy
- **E_g** = Band gap energy
- **r_E** = Energy integral correction factor.
- **W** = carrier temperature factor (electric field and ionization mean-free-path dependent).
- **T_e** = Electron temperature during avalanche.
- **α** = depleted region term (depends on e-field, ionization mean-free-path and optical phonon mean-free-path).
- **b** = mean-free-path for ionizing collisions.

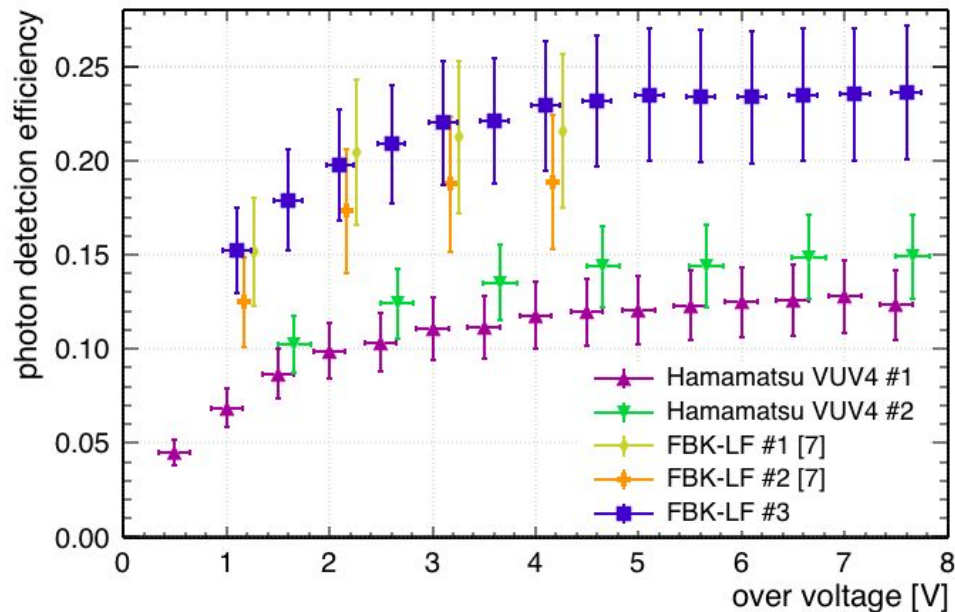
IEEE, DOI: 10.1109/16.760412

Photo-Detection-Efficiency

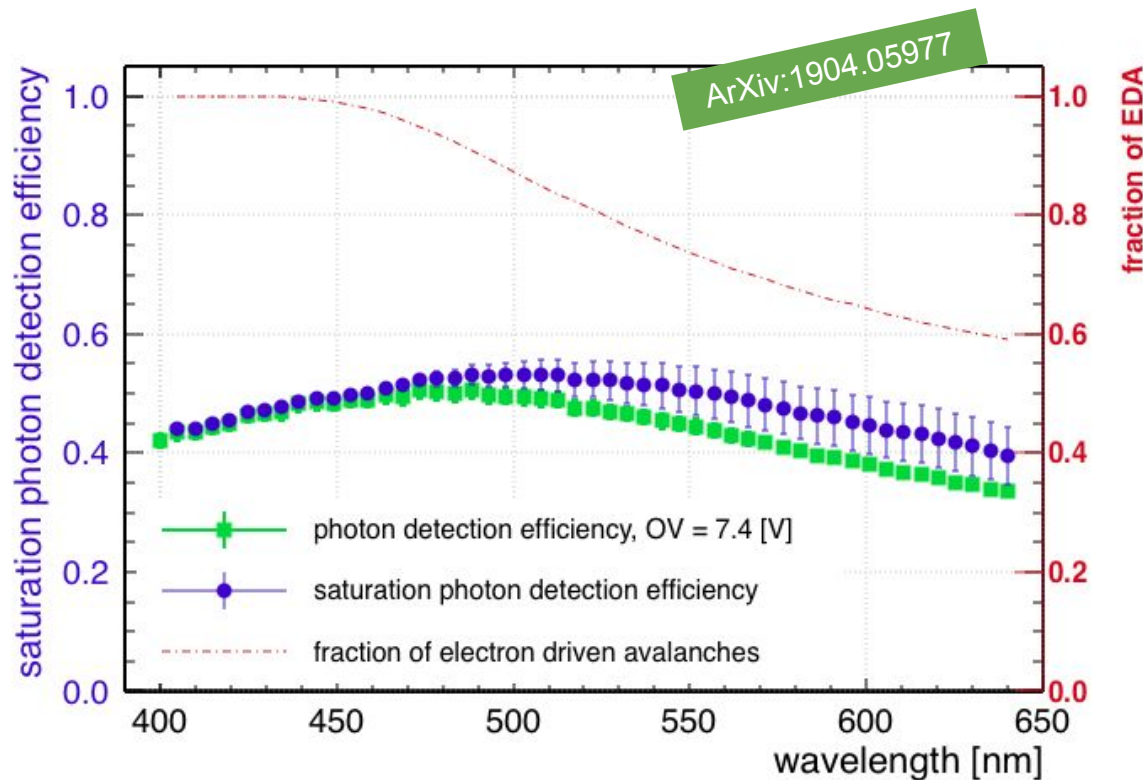
65



arXiv:1903.03663



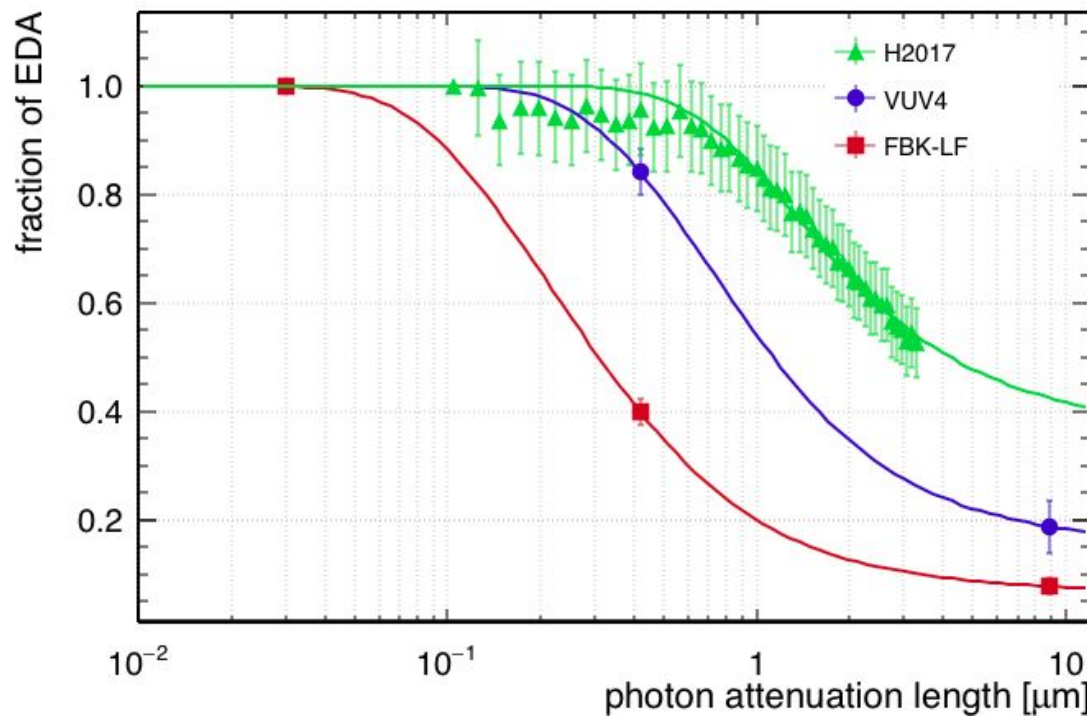
Avalanche-Triggering-Probability



Avalanche-Triggering-Probability

67

ArXiv:1904.05977



Boosting SiPM VUV Efficiency

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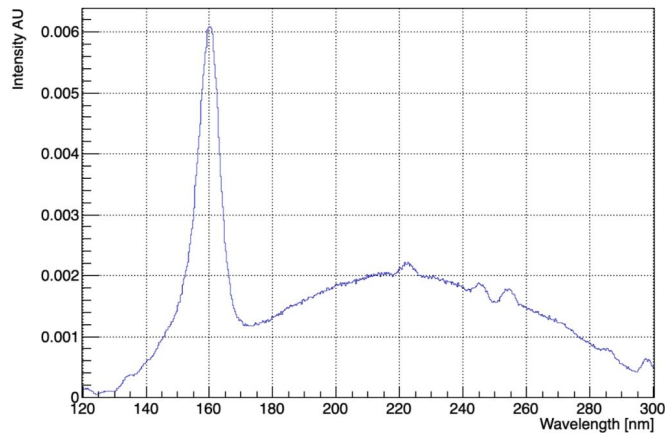
Photo Detection Efficiency:

Transmittance

Reflectivity

VUV Optics Game

Lamp Spectrum

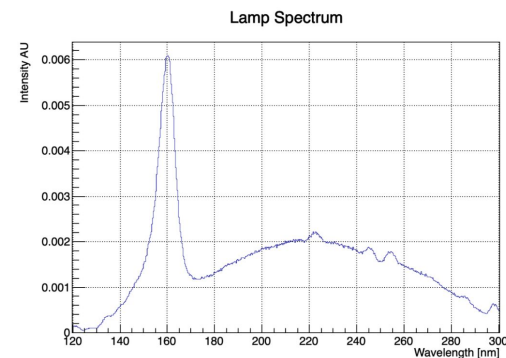
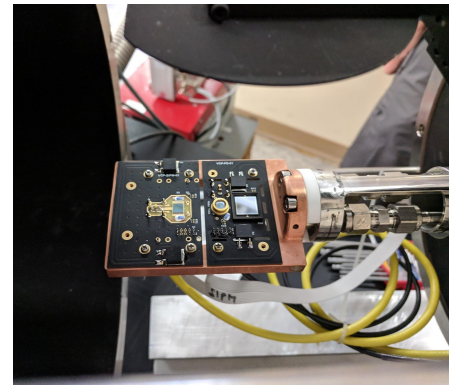
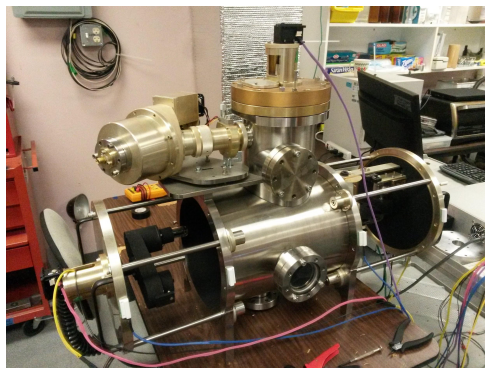
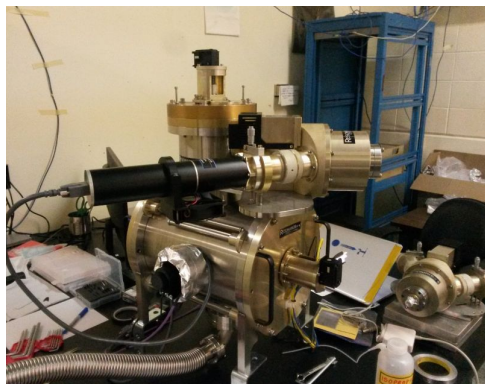
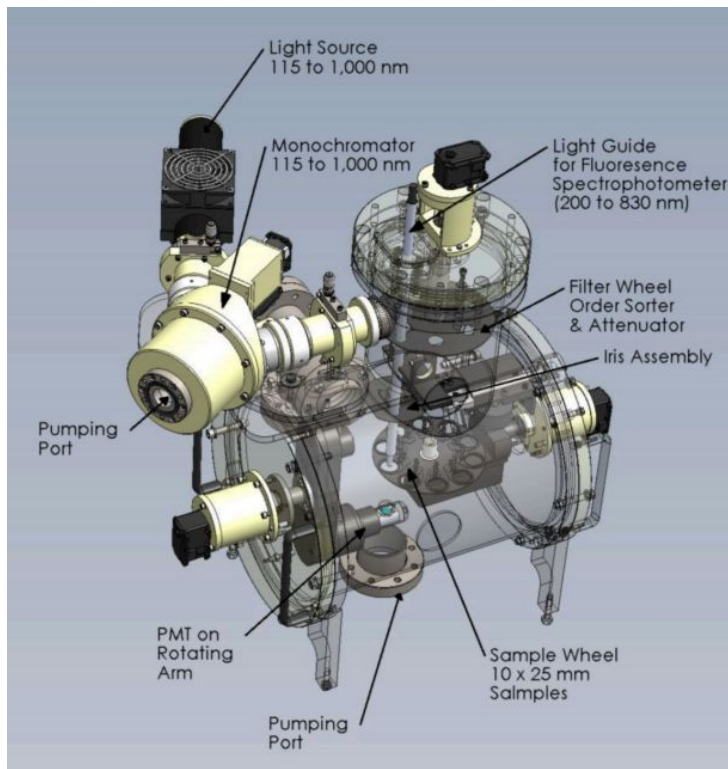


VUV Setup Design:

- Reflectance, Transmission, Fluorescence and more.
- Deuterium Lamp 100-400 nm continuous source spectrum.
- Advanced monochromator for precision wavelength selection.
- Ability to cool the sample to cryogenics temperatures.
- Ability to control the sample and readout position and tilt-angle.
- Reference PMT capable of sampling the beam via a parabolic mirror.
- Cryogenic sample holder with the ability to operate cold Diode/SiPM/PMTs.

VUV Optics and SiPM Characterization Setup

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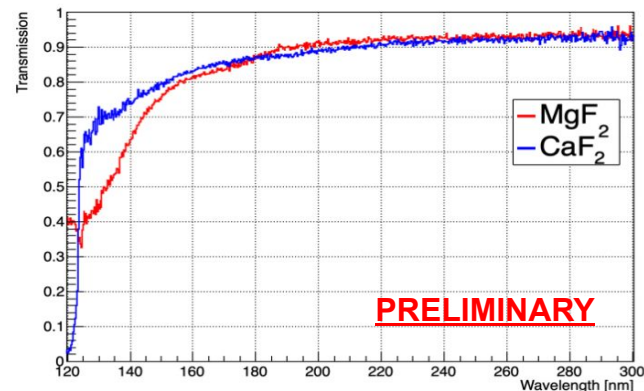
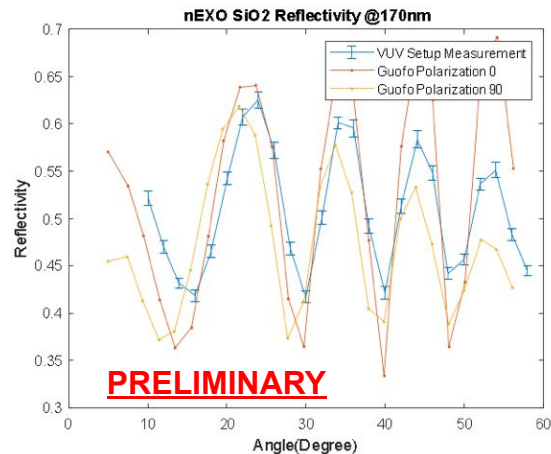
Early AR-Coating Results

AR Surface coating is critical for the ultimate VUV sensitive SiPM.
(Issue: Si reflectivity at ~175 nm is ~50%)
(SiO₂ has poor transmission ~128 nm).

Important to balance transmission and reflectivity to identify the most optimal AR surface coating for 3DSiPM.

Optical Material Selection Campaign:
Currently Under Investigation:

- Al₂O₃
- MgF₂
- LiF
- LaF₃
- Pure Al



TRIUMF Overview



Founded in 1968, TRIUMF is
Canada particle accelerator centre
(and much more).

